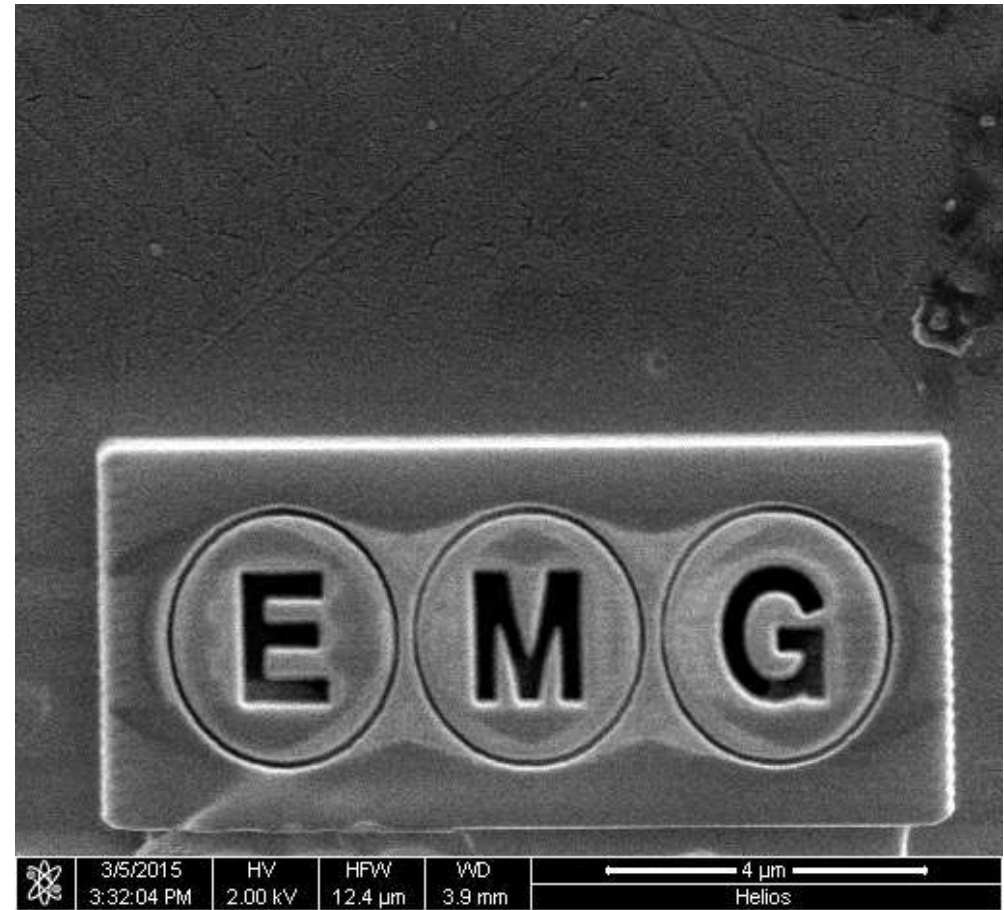


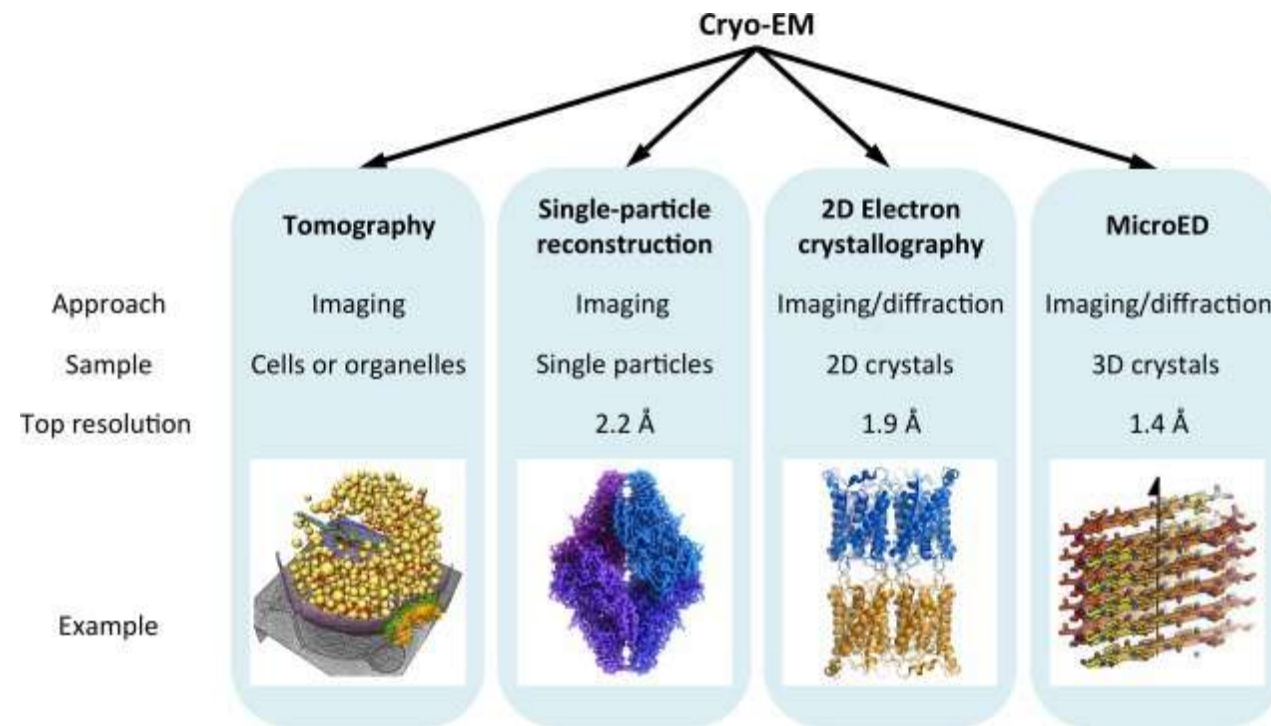
FIB SEM

March 4, 2024

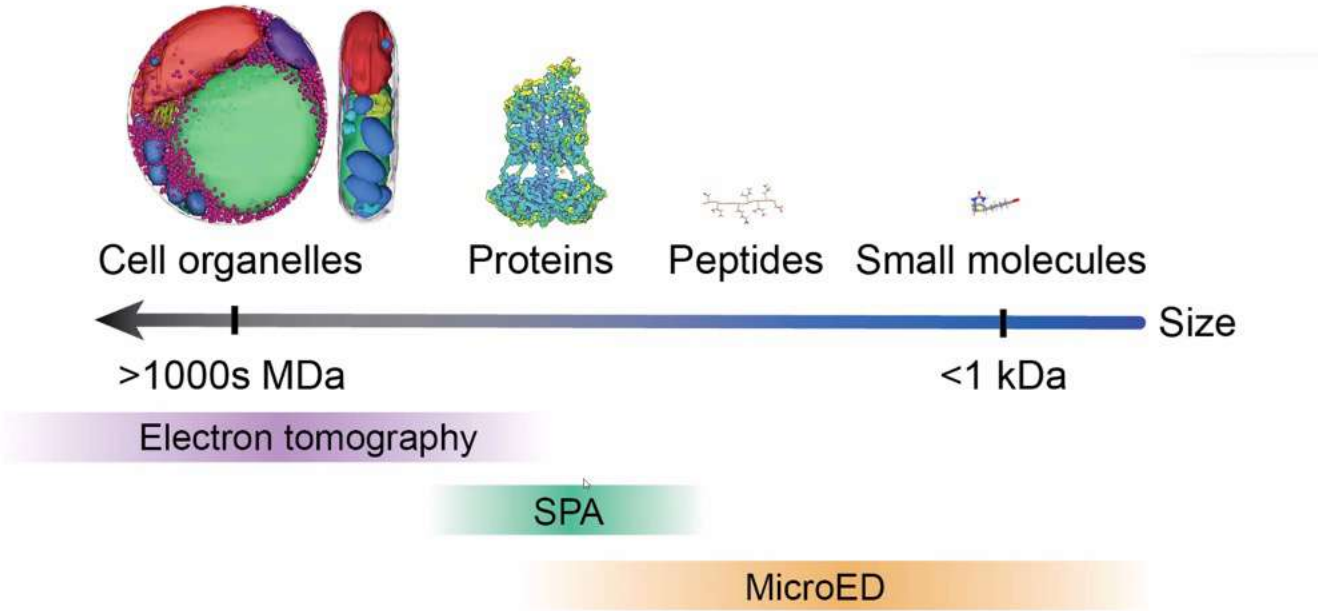
William Rice, NYU School of Medicine



Cryo-electron Imaging Modalities



Target Sizes

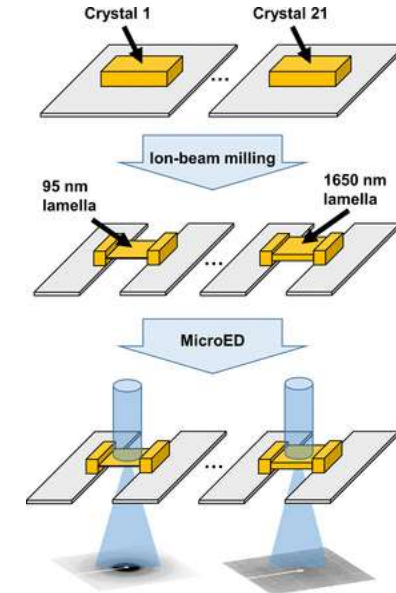


Sample thickness for TEM

- Lysozyme: crystals thicker than 500 nm unusable
- Martynowycz MW, Clabbers MTB, Unge J, Hattne J, Gonen T. Benchmarking the ideal sample thickness in cryo-EM. Proc Natl Acad Sci U S A. 2021 Dec 7;118(49):e2108884118. doi: 10.1073/pnas.2108884118. PMID: 34873060; PMCID: PMC8670461.
- Maximum usable thickness $\sim 2X$ mean free path of electrons
 - 120 keV: 430 nm
 - 200 keV: 540 nm
 - 300 keV: 640 nm

Thickness increases by a factor of $1/\cos(\theta)$

60° tilt: twice as thick as nominal untilted

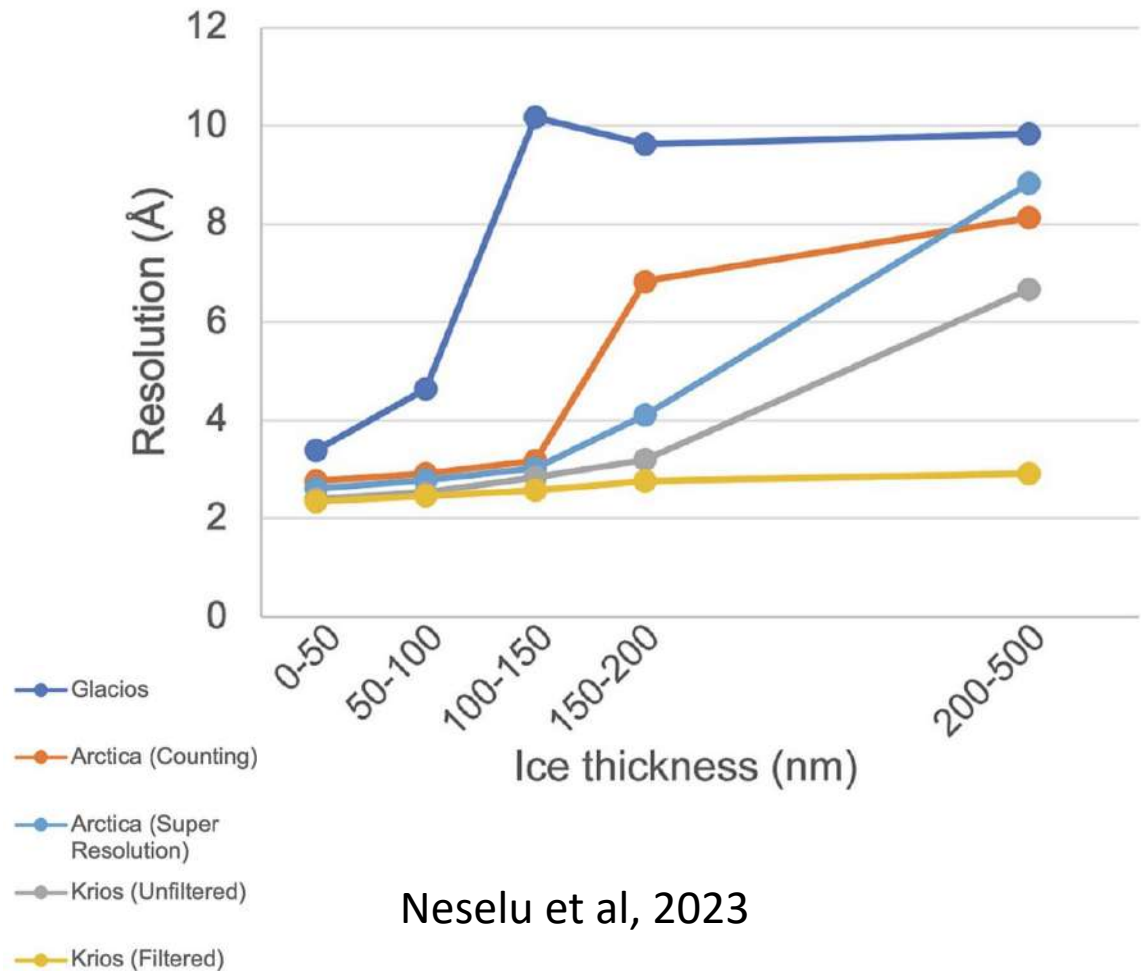


Typical sample thickness

- Single particle samples: 10nm – 200 nm
- Bacterial cell: 1-2 μm
- Typical eukaryotic cell: 5 μm
- Tissue samples: up to 200 μm

(A)

Resolution vs ice thickness



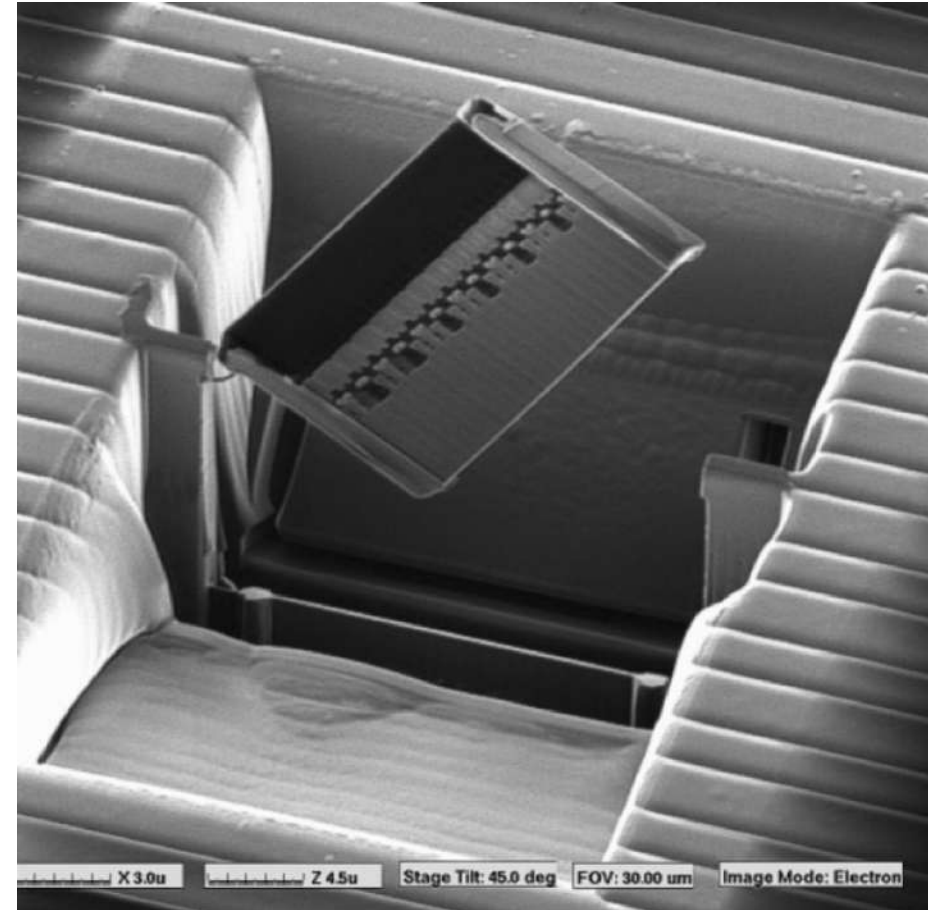
Neselu et al, 2023

Solutions

- Megavolt electron microscopes
 - Not commercially available
 - Space requirements: 2+ stories
 - X-ray safety
 - Detectors
- Microtomy
- Cryomicrotomy (CEMOVIS) is difficult
 - Sections hard to pick up
 - May be difficult to place on grids
 - Compression and knife artifacts

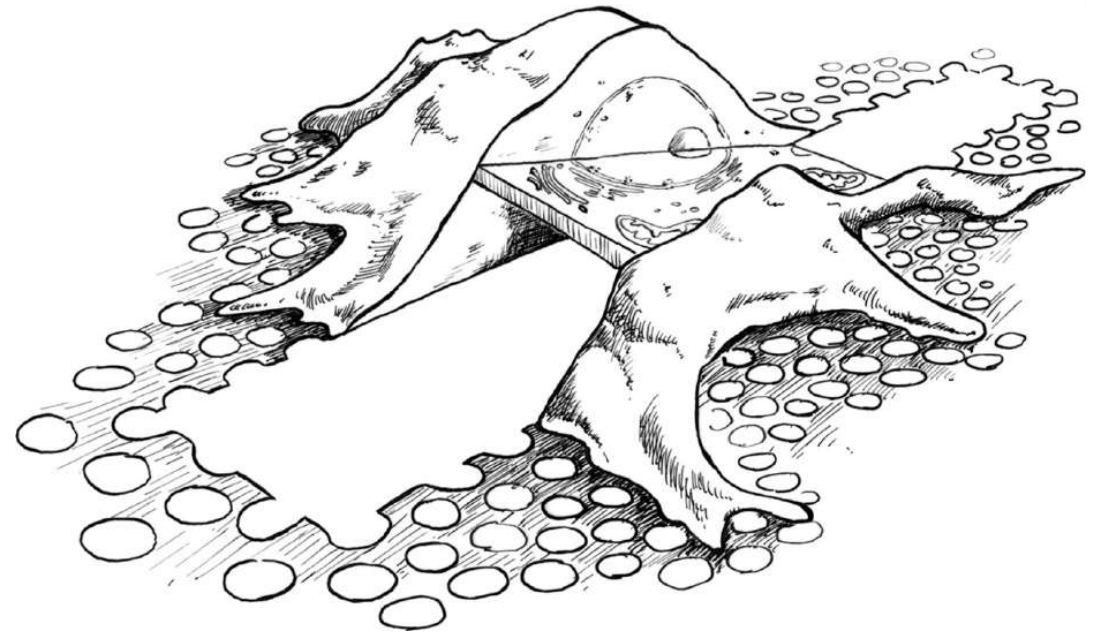
Solutions

- Use a focused ion beam to thin the sample
- Cut out a thin (electron transparent) piece then place on a standard EM grid for TEM imaging



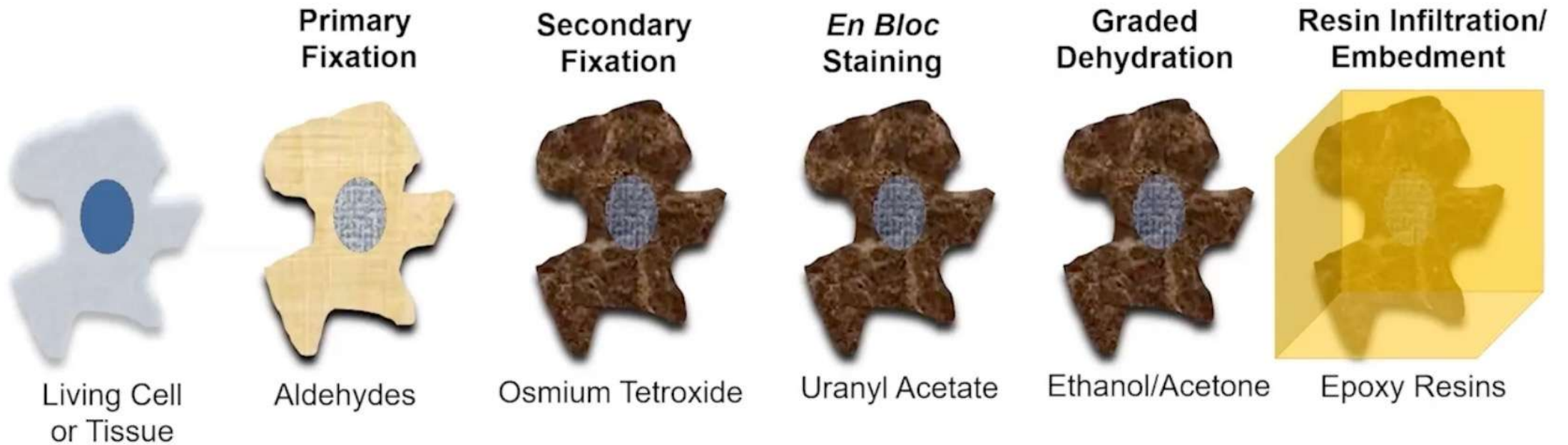
Solutions

- Use a focused ion beam to carve out a thin lamella from a frozen sample
- Transfer to cryo-TEM

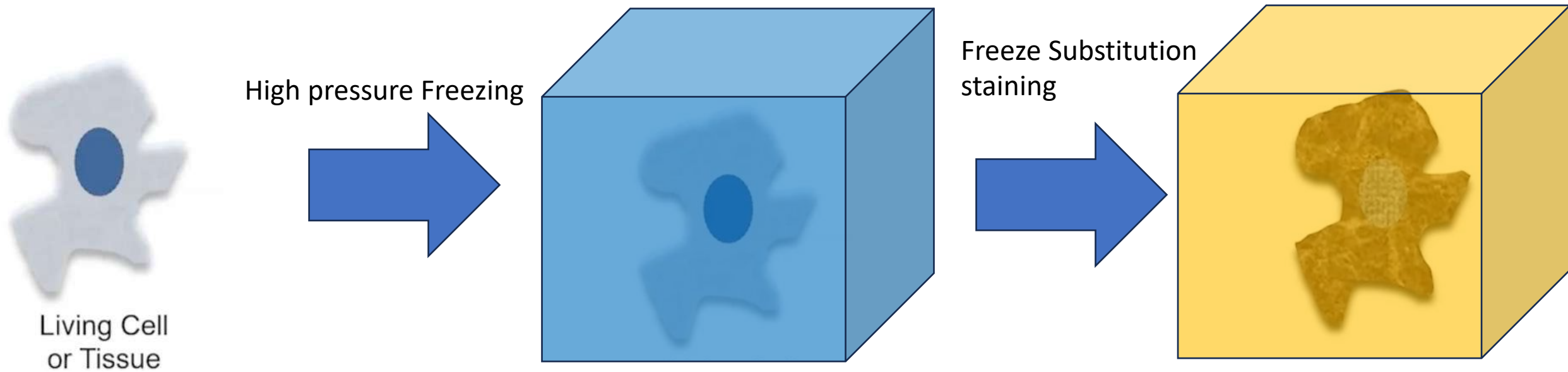


Types of Samples

Room temperature Samples



Freeze Substituted Samples



Living Cell
or Tissue

High pressure Freezing

Freeze Substitution
staining

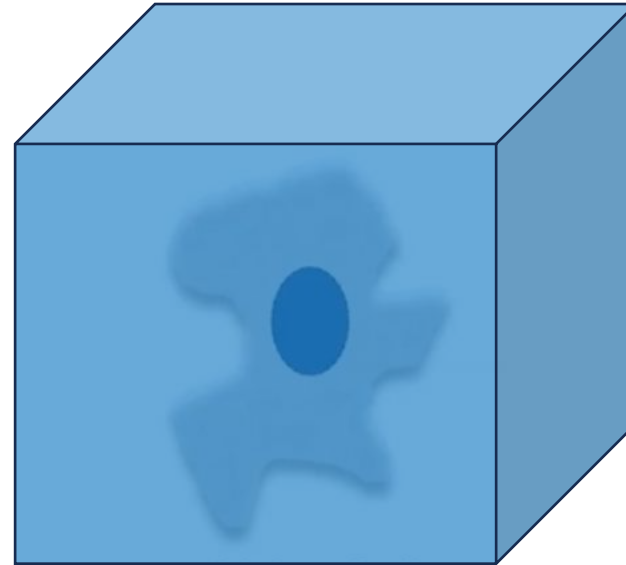
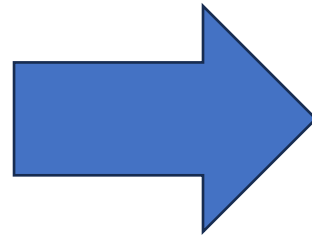
Size limit: $\sim 200 \mu\text{m}$ thick

Frozen Samples



Living Cell
or Tissue

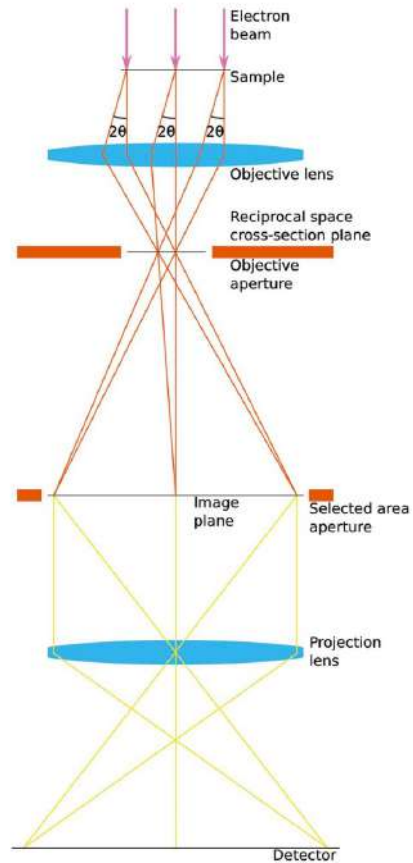
High pressure Freezing



SEM Basics

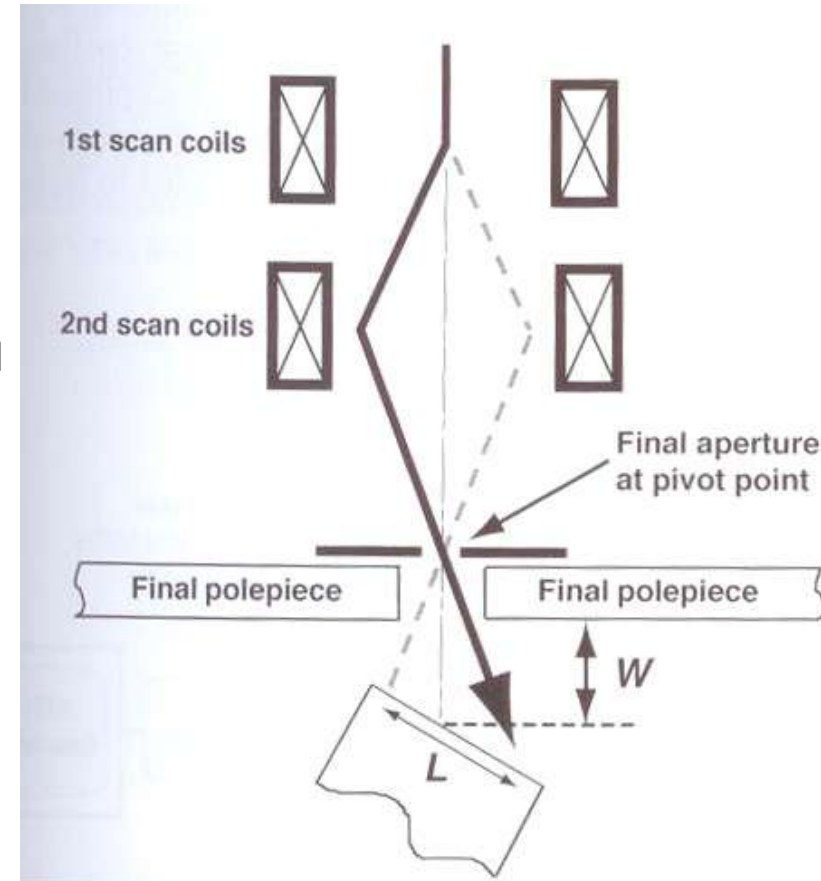
SEM versus TEM

TEM



Projection through sample

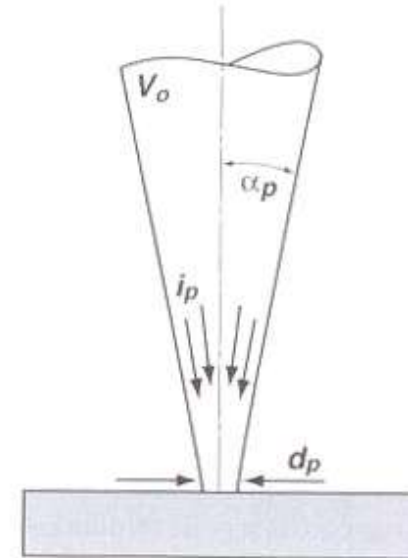
SEM



Surface imaging

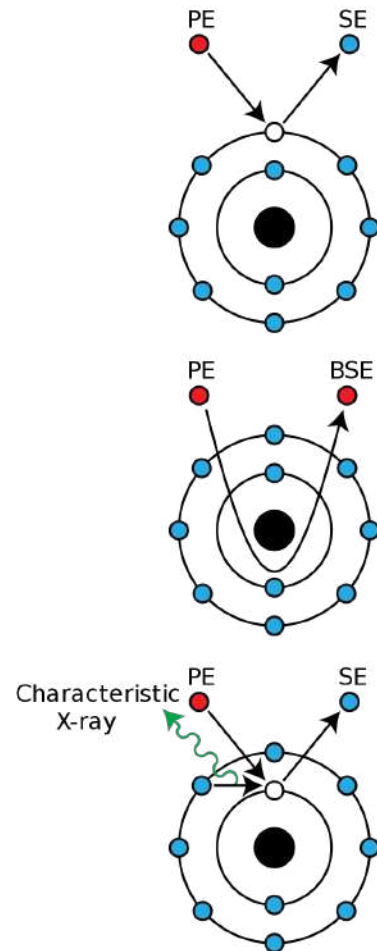
SEM Beam: probe size

- ◆ Ideally want as small a probe as possible, relative to pixel size
- ◆ Probe size is determined by voltage, current, divergence angle
- ◆ Lens distortions
 - ◆ Spherical aberration (focus different at center and edge of lens) – proportional to focal length (working distance)
 - ◆ Aperture diffraction
 - ◆ Astigmatism (user correctable)
 - ◆ Chromatic aberration – voltage dependent (higher at low voltage)

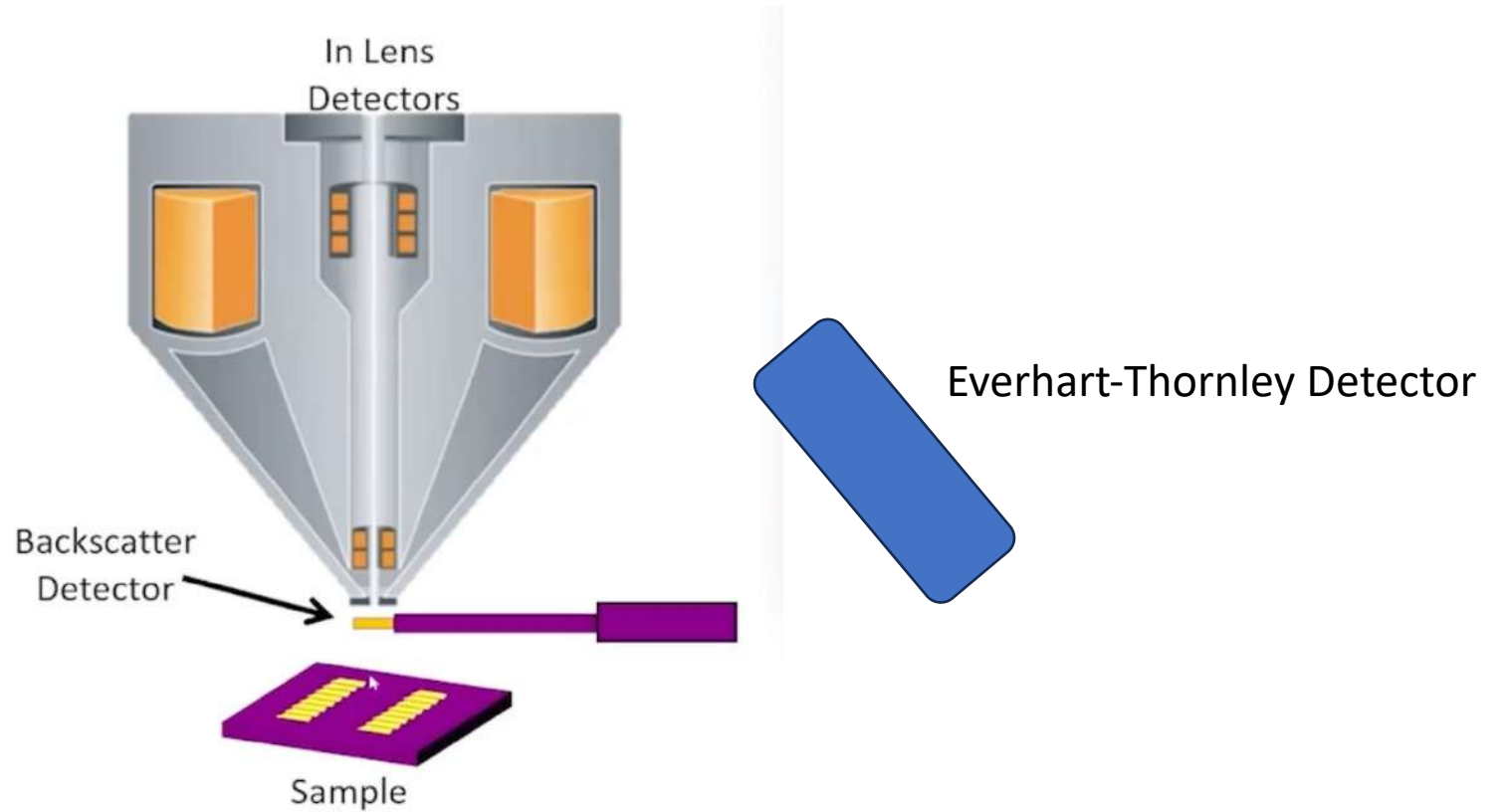


Goldstein et al, 2003

Signal: Back Scattered Electrons (BSE's) and Secondary Electrons (SE's)

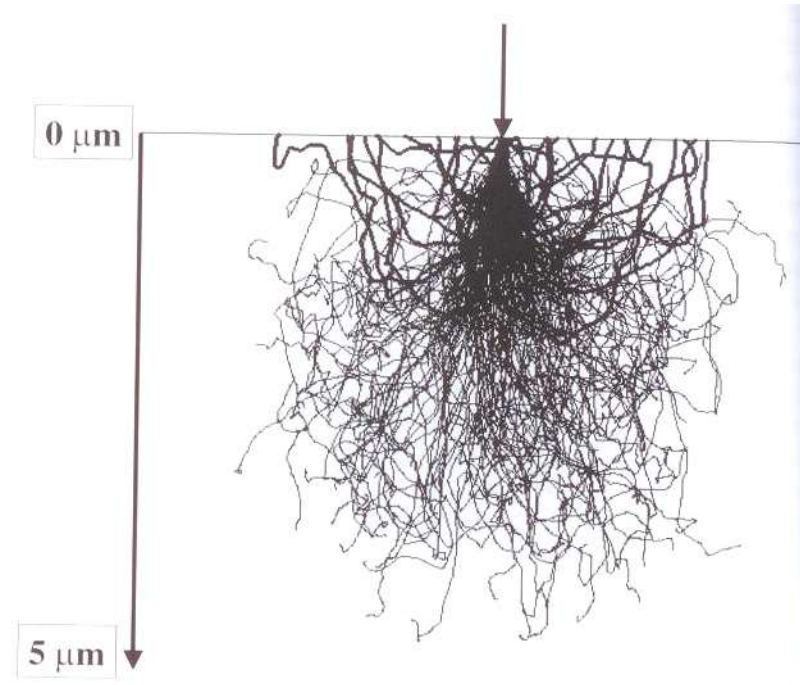


Detector Setup for SEM



Beam-Specimen Interaction

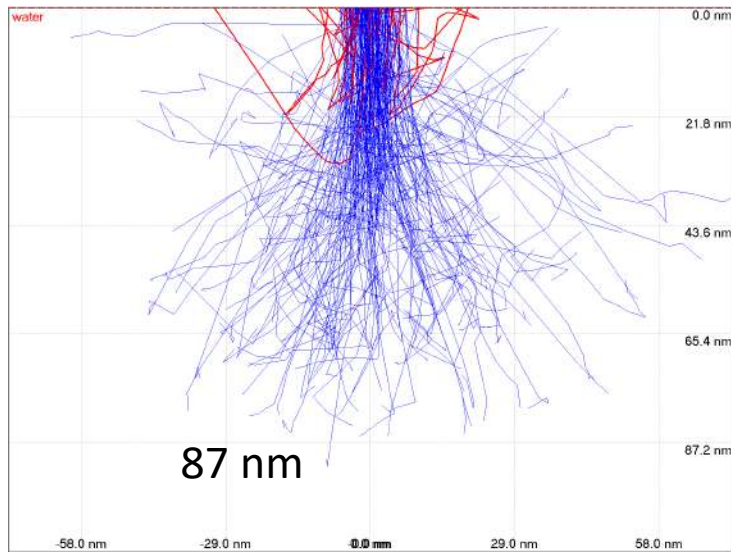
- Monte Carlo simulation of a 20 keV beam in Si
 - Dark traces: electrons which left the sample (BSE's)
- Electrons may be scattered elastically or inelastically
- Probability of elastic scattering $\sim Z^2$
- Inelastic scattering:
 - Secondary electrons
 - X-rays



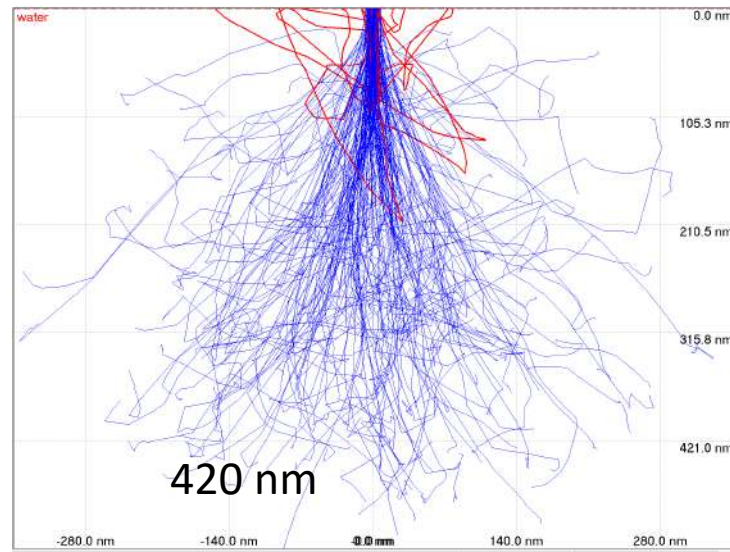
Goldstein et al, 2003

Monte Carlo simulation: water

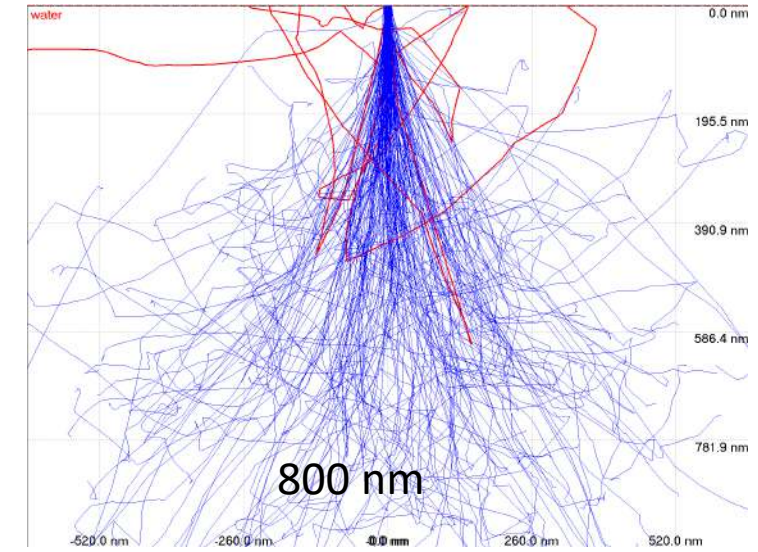
1 KEV



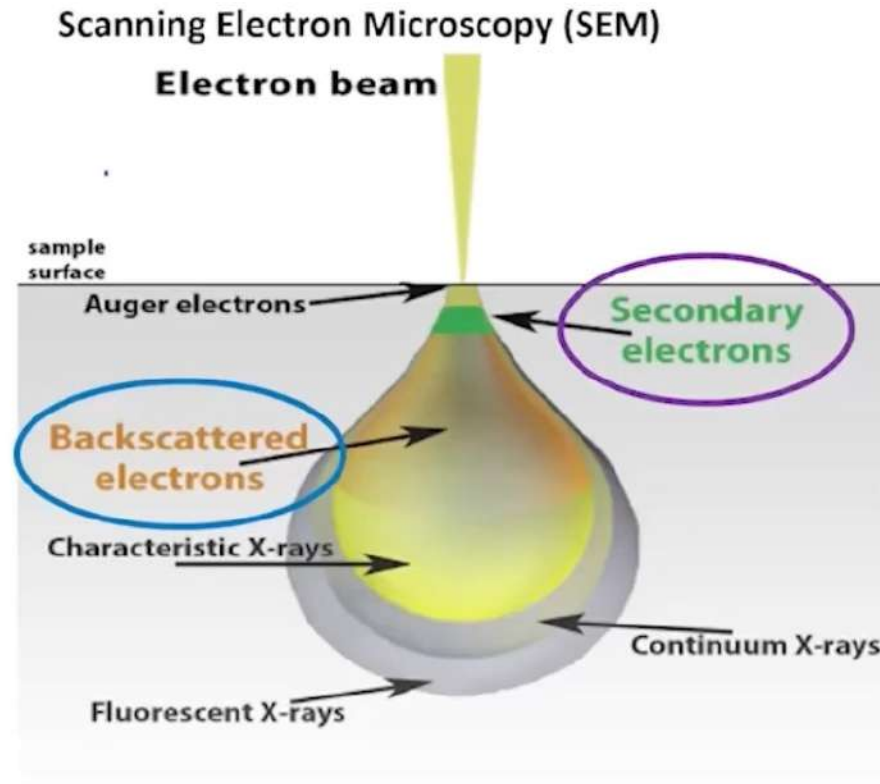
3 KEV



5 KEV

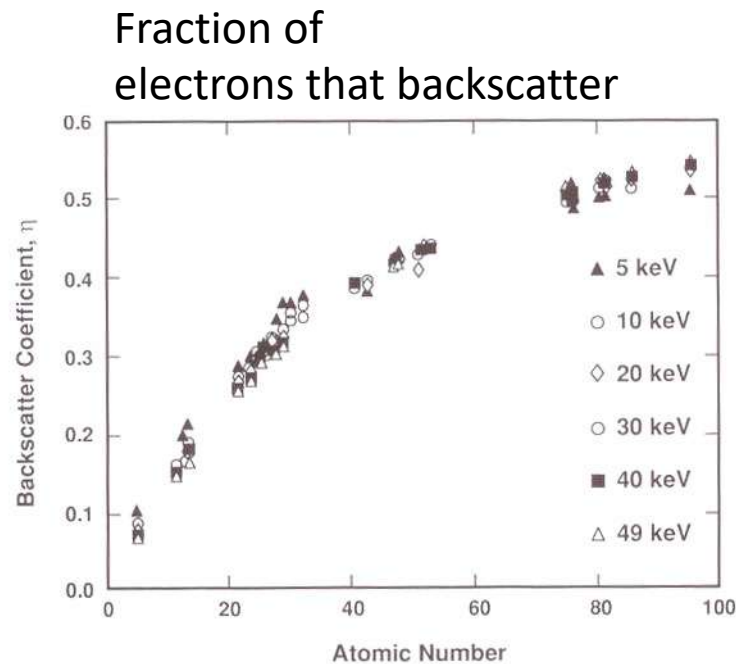


Interaction Volume



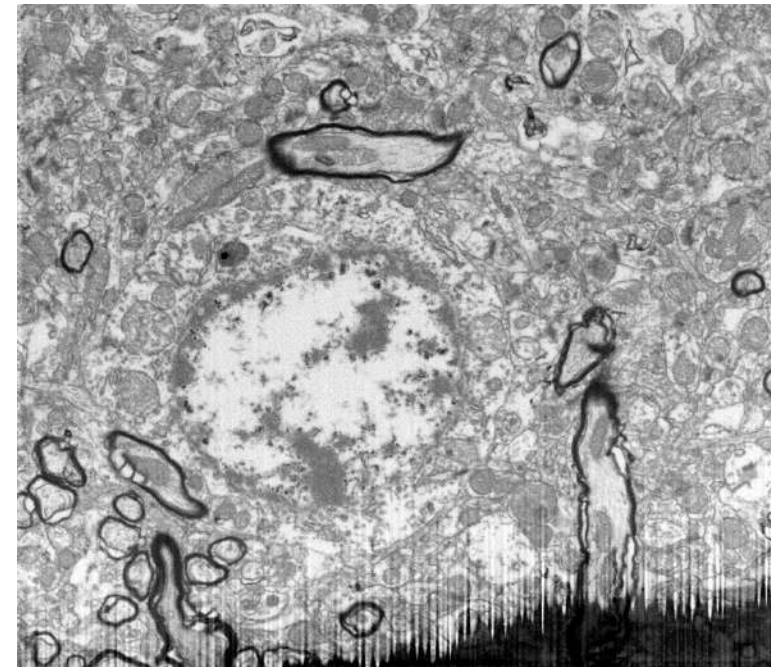
Schematic of electron beam interaction

BSE efficiency is material dependent, voltage independent



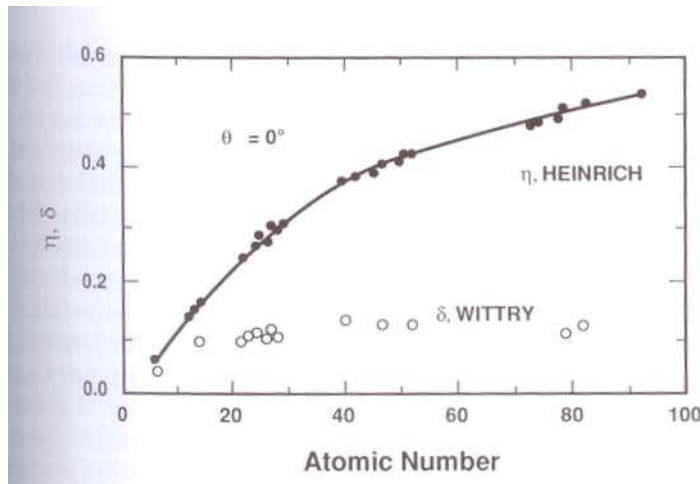
Goldstein et al, 2003

BSE's give contrast between light and heavy elements



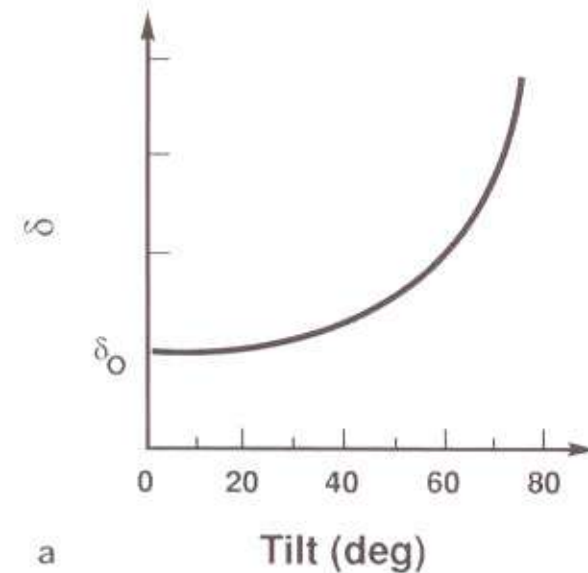
Osmium stained, resin-embedded tissue

Secondary Electrons are much less sensitive to element difference, more sensitive to topographic information



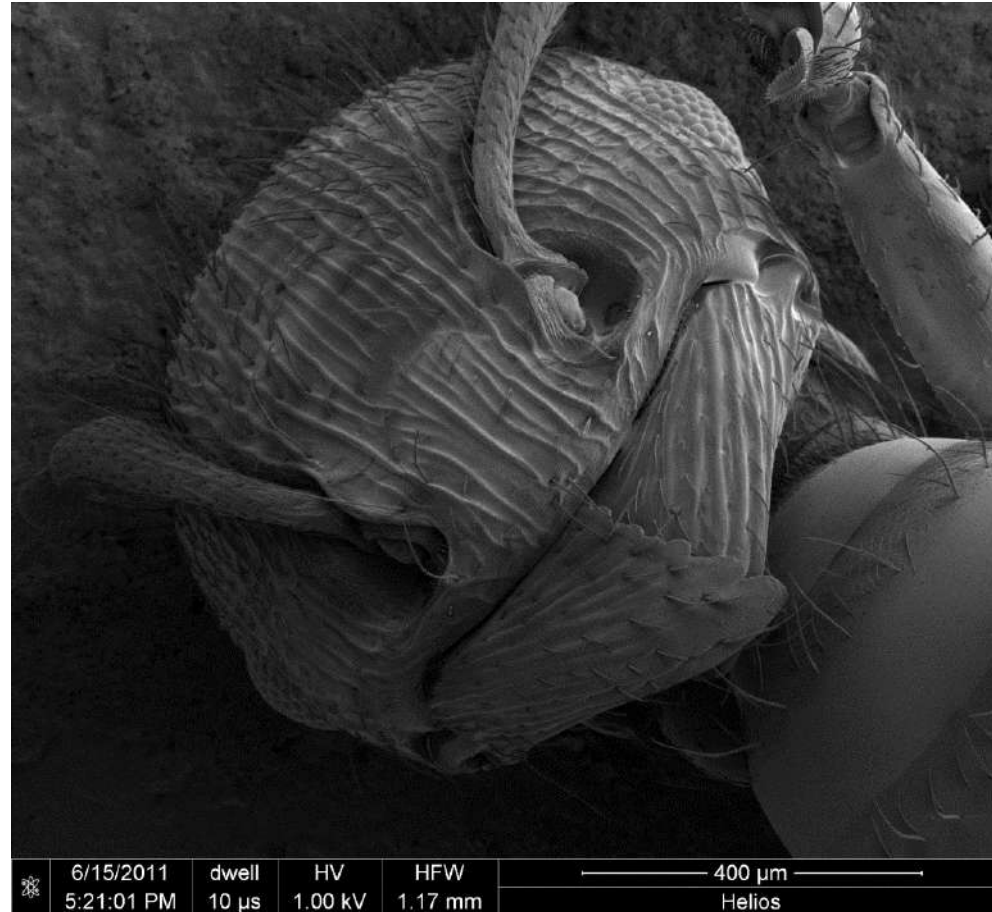
30 keV

SE's are less sensitive to atomic number than BSE's
(may be more sensitive at lower beam energies)



Signal is strongly dependent on viewing direction

SE's give excellent topographic information



Non-conductive samples

- Imaging with electrons on non-conductive samples is difficult due to charging artifacts
 - Resin-embedded samples, biological specimens, frozen samples
- Generally make them conductive beforehand by sputter-coating with metal (Pt, Au)
- Image using low voltage (5 keV or less) and low current
 - Current too low requires longer scan/integration times
- Ideally, the SEM includes a pre-loading chamber for sputter coating

SEM versus TEM

SEM

- Large chamber
 - Harder to reach highest vacuum
 - Many ports for add-ons
- Voltage: < 1 keV to 30 keV
 - Commonly <5 keV for non-conductive specimens
- Large samples of varying shape
- Signal from surface or just beneath surface
- Non-coherent imaging, no phase information

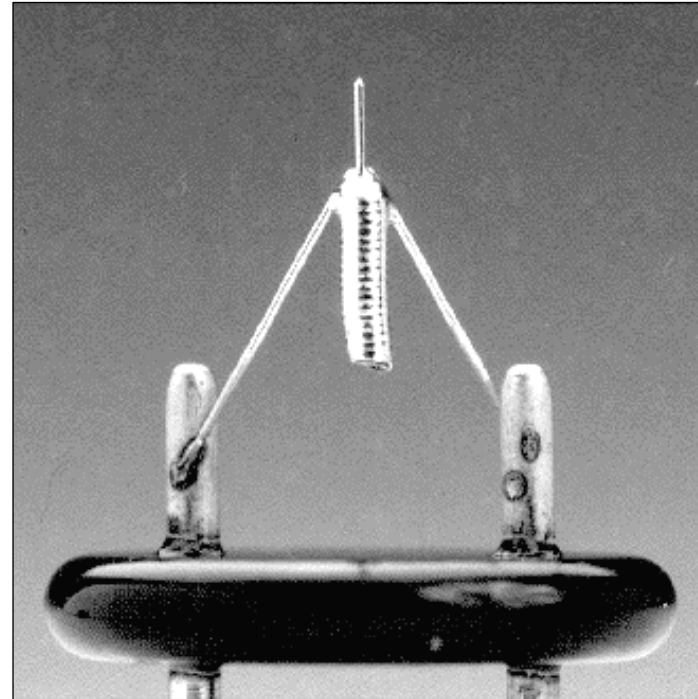
TEM

- Small Chamber
 - Easier to reach very high vacuum
 - Few ports for add-ons
- Voltage: 80-300 keV
 - 300 keV for highest resolution
 - Lower voltage DED now being released
- Thin samples (<500 nm) on TEM grid
- Projection images through sample
- Coherent beam imaging: phase preserved

FIB Operation

Gallium is the Most Popular LMIS

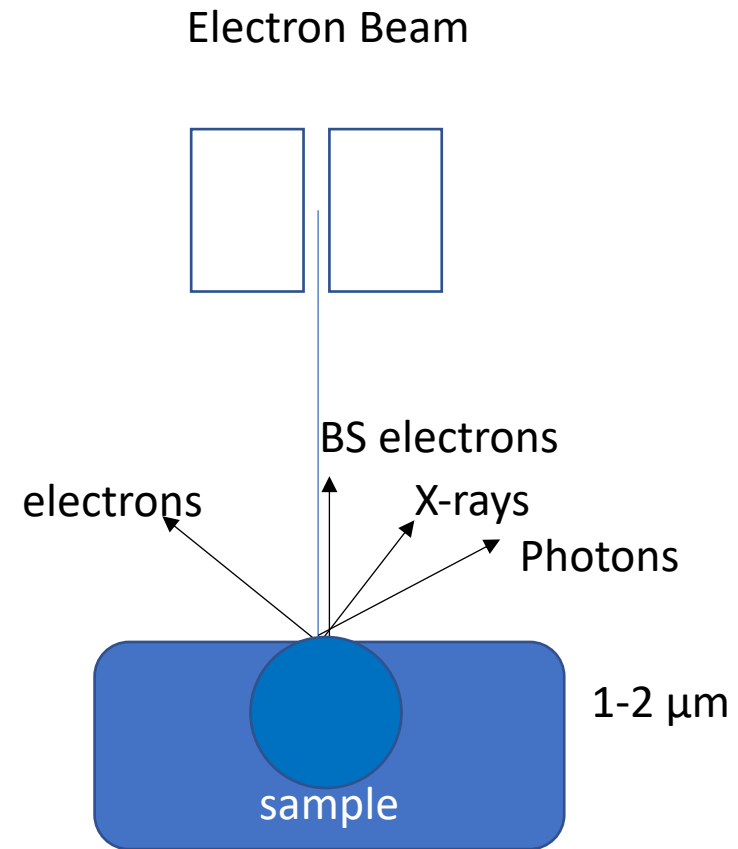
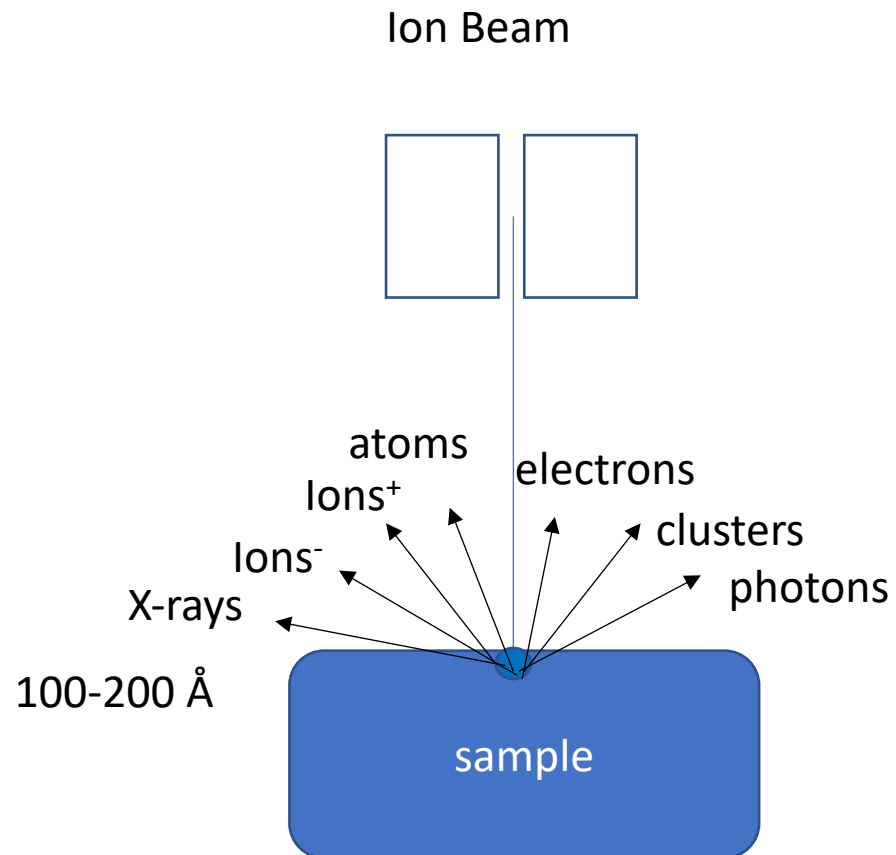
- ◆ A liquid metal
- ◆ Room temperature operation
- ◆ Long lived (500-1500 hr sources)
- ◆ High vacuum compatible
- ◆ Large ion for sputtering
- ◆ Other options
 - ◆ He, Ne, Xe
 - ◆ Mostly for materials sciences



Ion Column

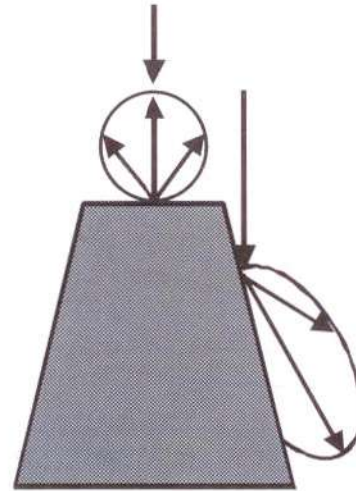
- ◆ Source - LMIS at top
- ◆ Focusing Optics
 - Use Electrostatic lenses since ions are heavier than electrons.
- ◆ Deflection Electronics/Pattern Board
- ◆ High-speed Blanking
 - Need to prevent milling while blanking
- Current is controlled by apertures
 - Apertures wear out over time and must be replaced!
- You can get images with FIB beam. Beam is much more damaging than electron beam so you need to image at as low current as possible
- Generally used at 30 keV, though voltage can be changed

Beam Interactions with Specimens



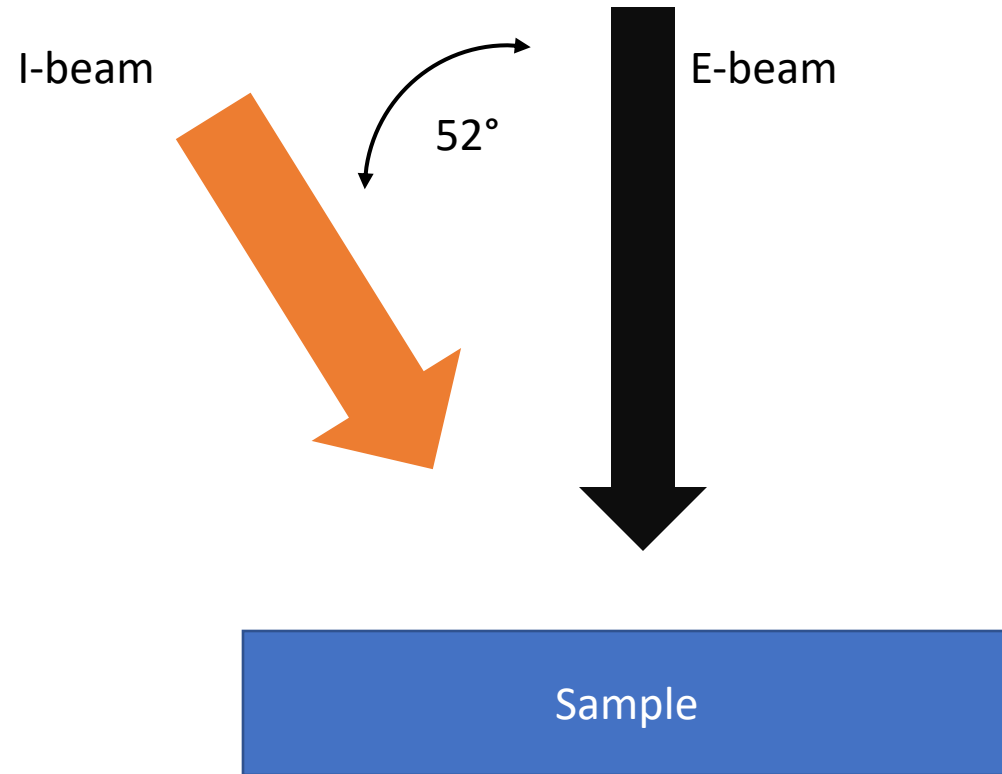
Common Use: Sputtering particles from substrate

Sputtered Particle Ejection Behavior



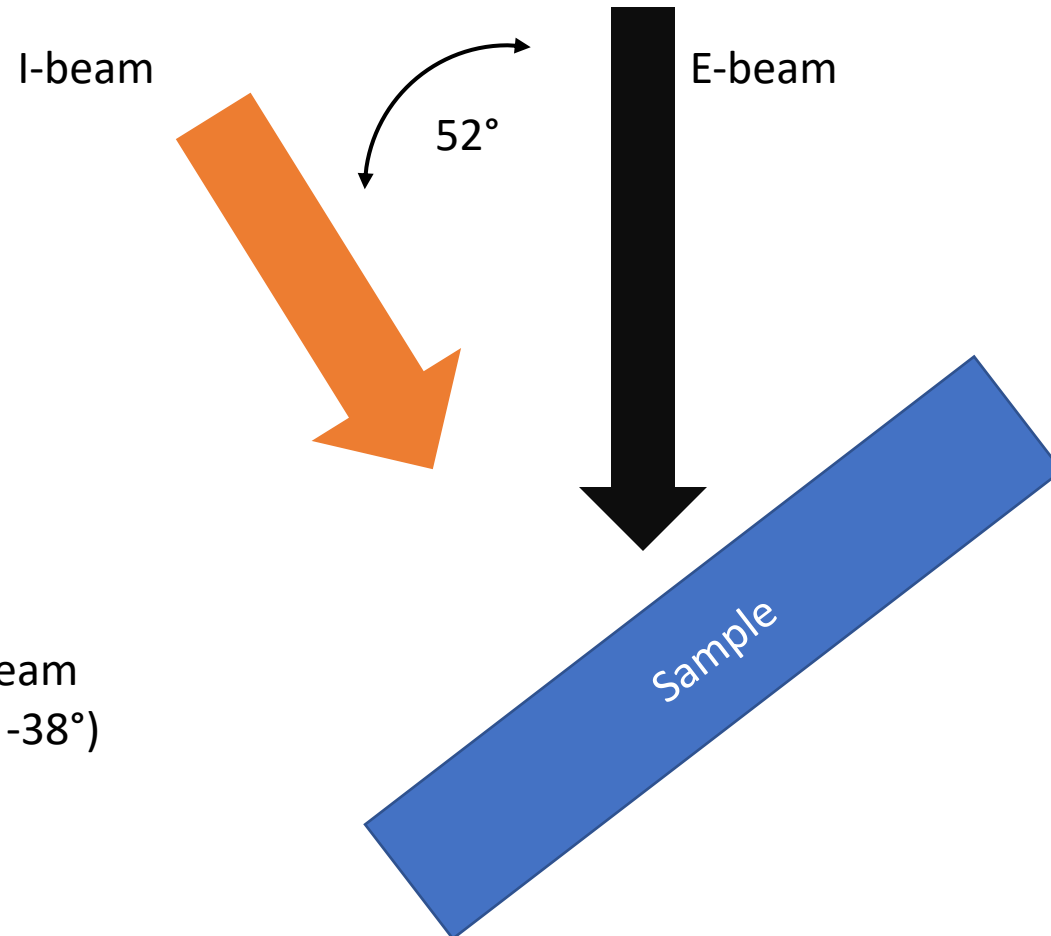
More efficient milling at edge than in bulk

Geometry



Sample:
Tilt from -10° to $+70^\circ$

Geometry



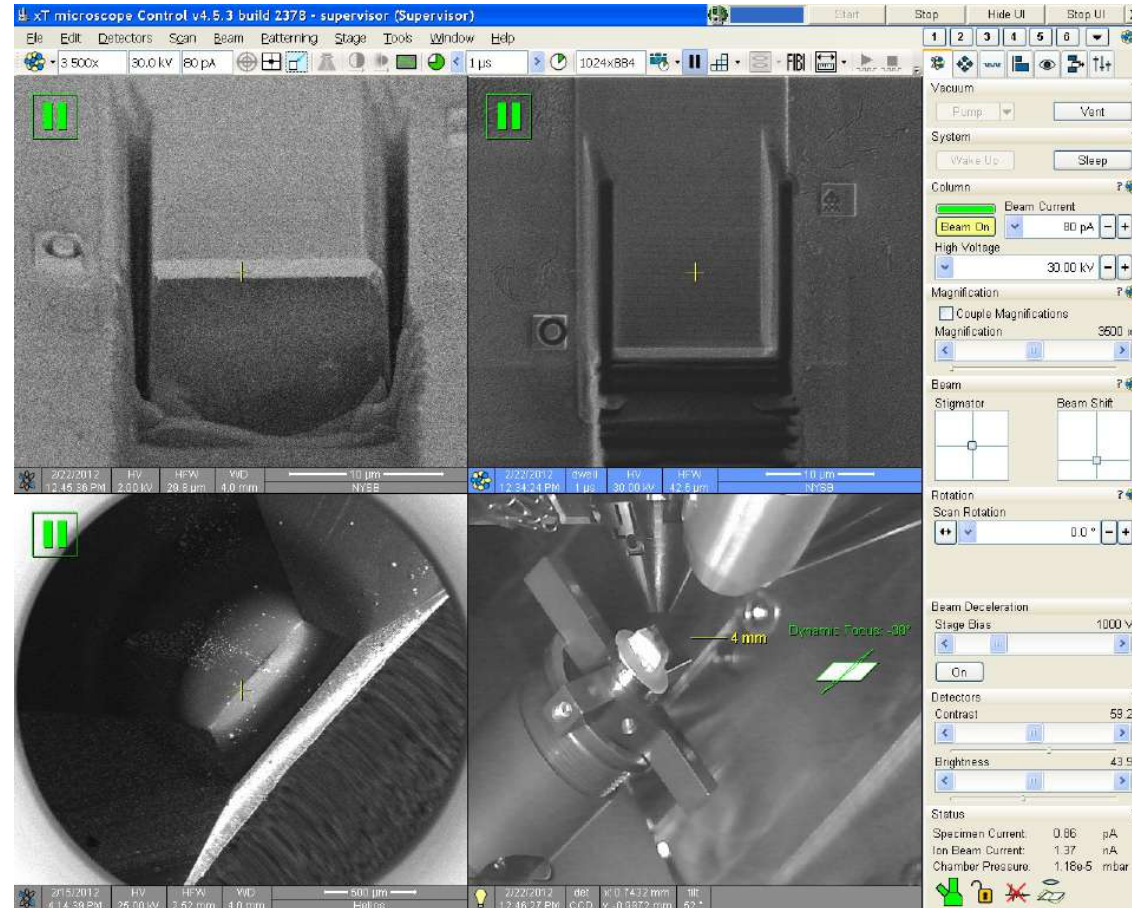
Sample:

Tilt from -10° to $+70^\circ$

Tilt to 52° for orthogonal i-beam

(cross-section viewing angle -38°)

Geometry



Metal Deposition for surface protection (GIS)

- (Methylcyclopentadienyl) trimethyl platinum
- Warm to gas, spray over sample with needle
- I-beam or e-beam interactions break it apart, deposit metal onto sample
 - Protection
 - Hard surface for mill
 - Prevents “curtaining”

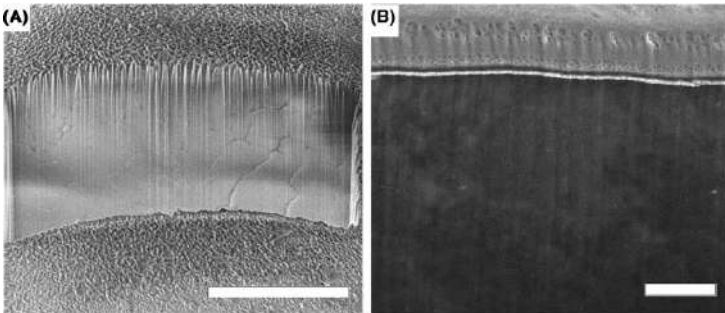
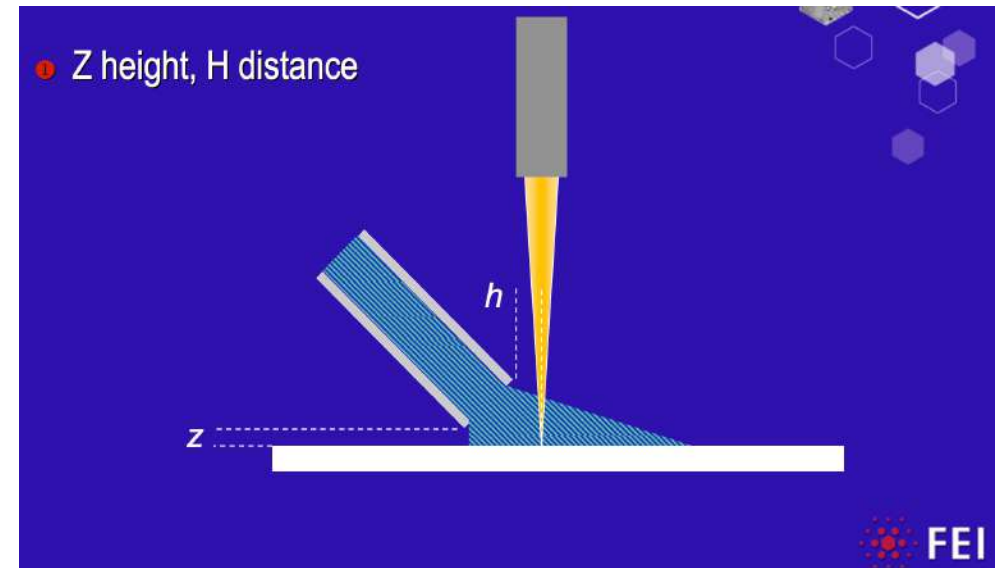
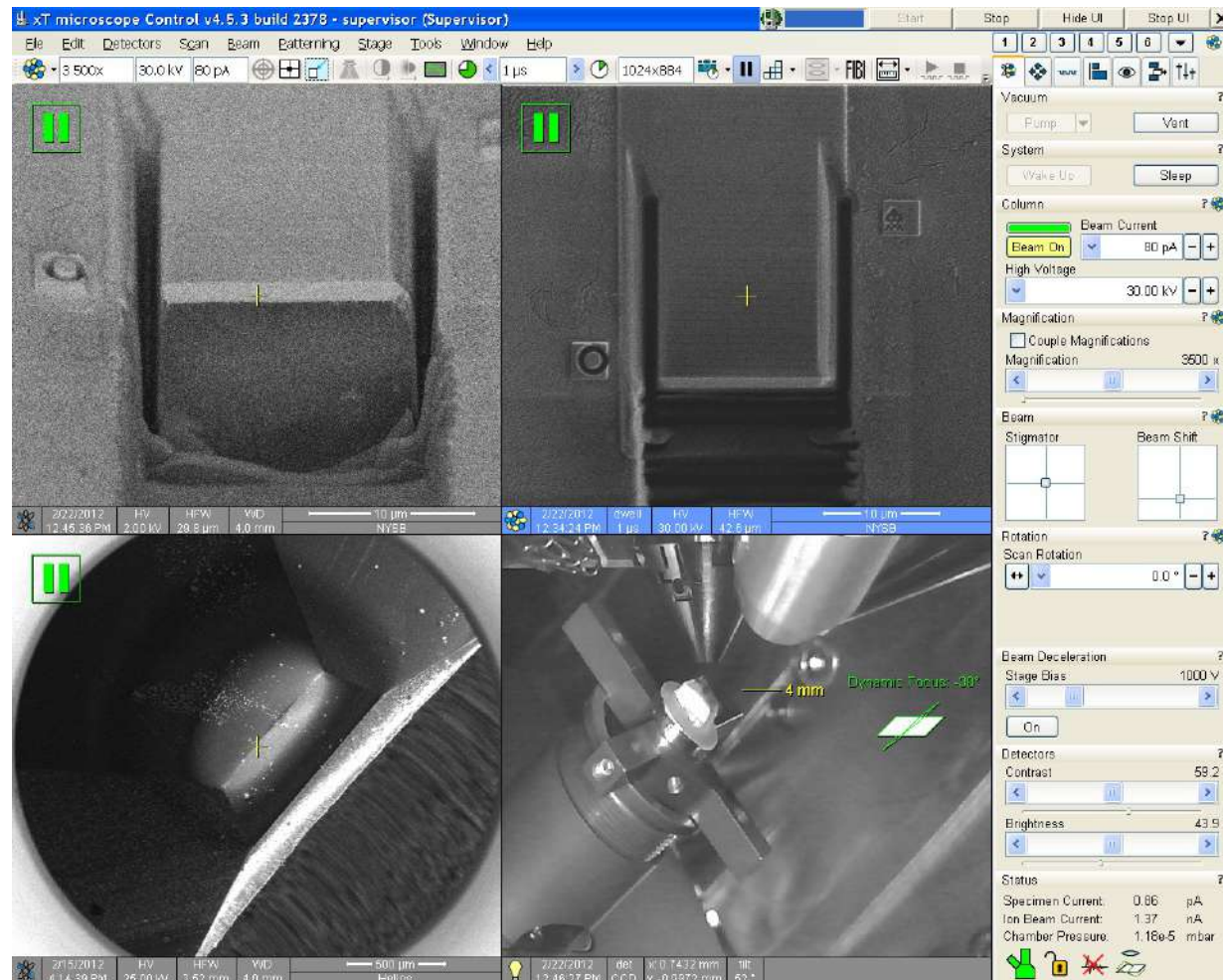


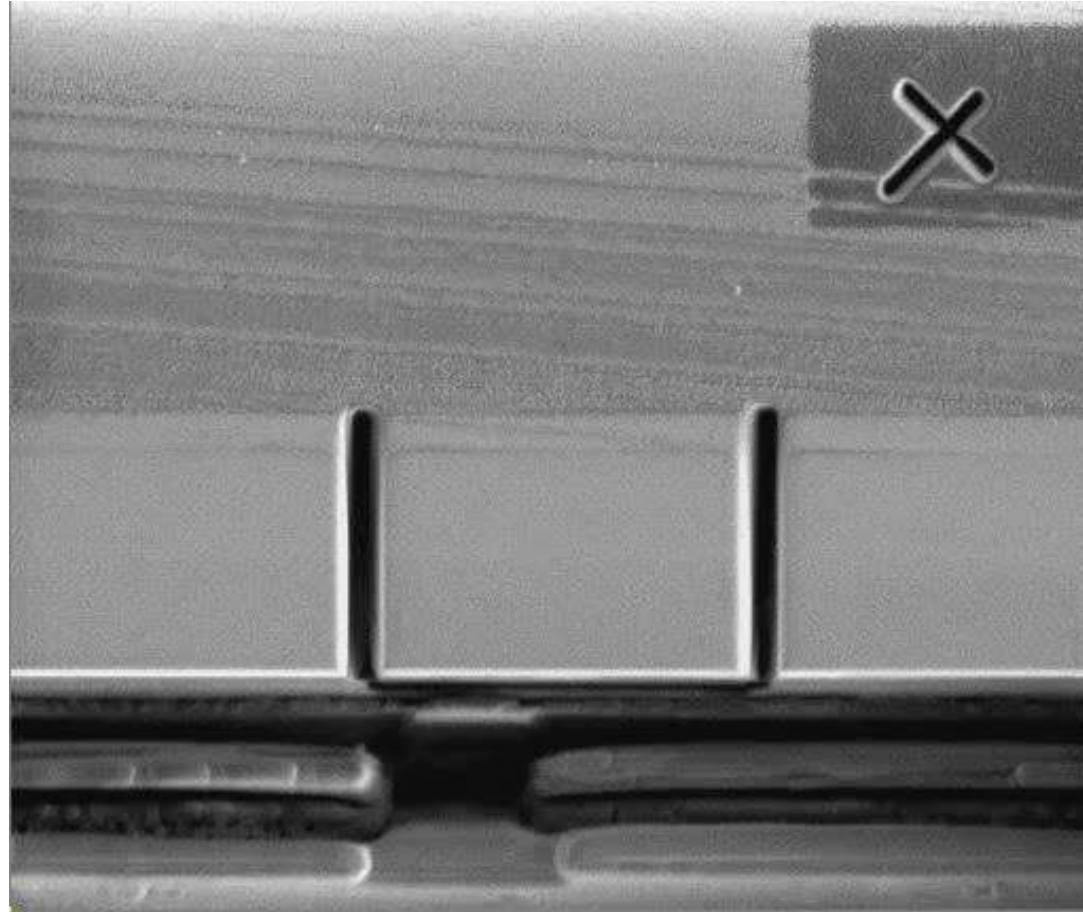
Image: Hayles and Winter, 2021



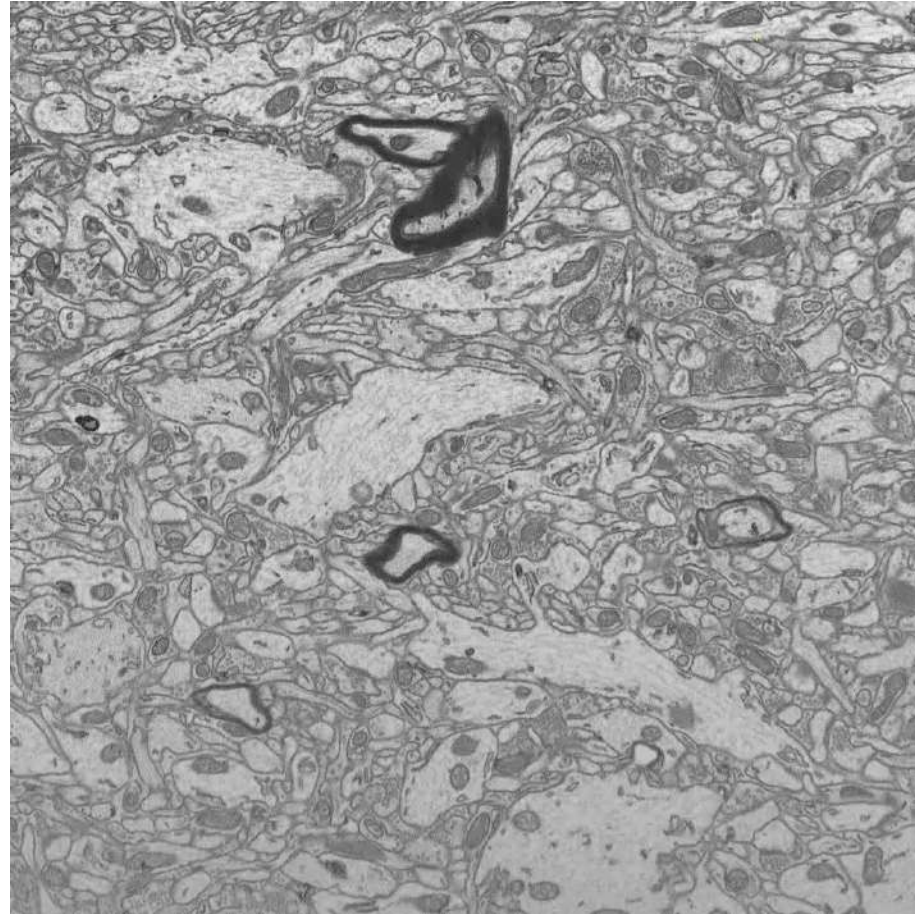
Application: 3D reconstruction of stained, freeze substituted resin-embedded tissue



Milling: i-beam view



Example Movie: Neural Tissue



Volumetric imaging with
nearly isotropic pixels

Cryo-SEM imaging

Technical Note

Cryo FIB-SEM: Volume imaging of cellular ultrastructure in native frozen specimens



Andreas Schertel^{a,1}, Nicolas Snaidero^{b,1}, Hong-Mei Han^c, Torben Ruhwedel^d, Michael Laue^e,
Markus Grabenbauer^{c,2}, Wiebke Möbius^{d,f,*}

^a Carl Zeiss Microscopy GmbH, Training, Application and Support Center (TASC), Carl-Zeiss-Straße 22, D-73447 Oberkochen, Germany

^b Cellular Neuroscience, Max Planck Institute of Experimental Medicine, Hermann-Rein-Straße 3, D-37075 Göttingen, Germany

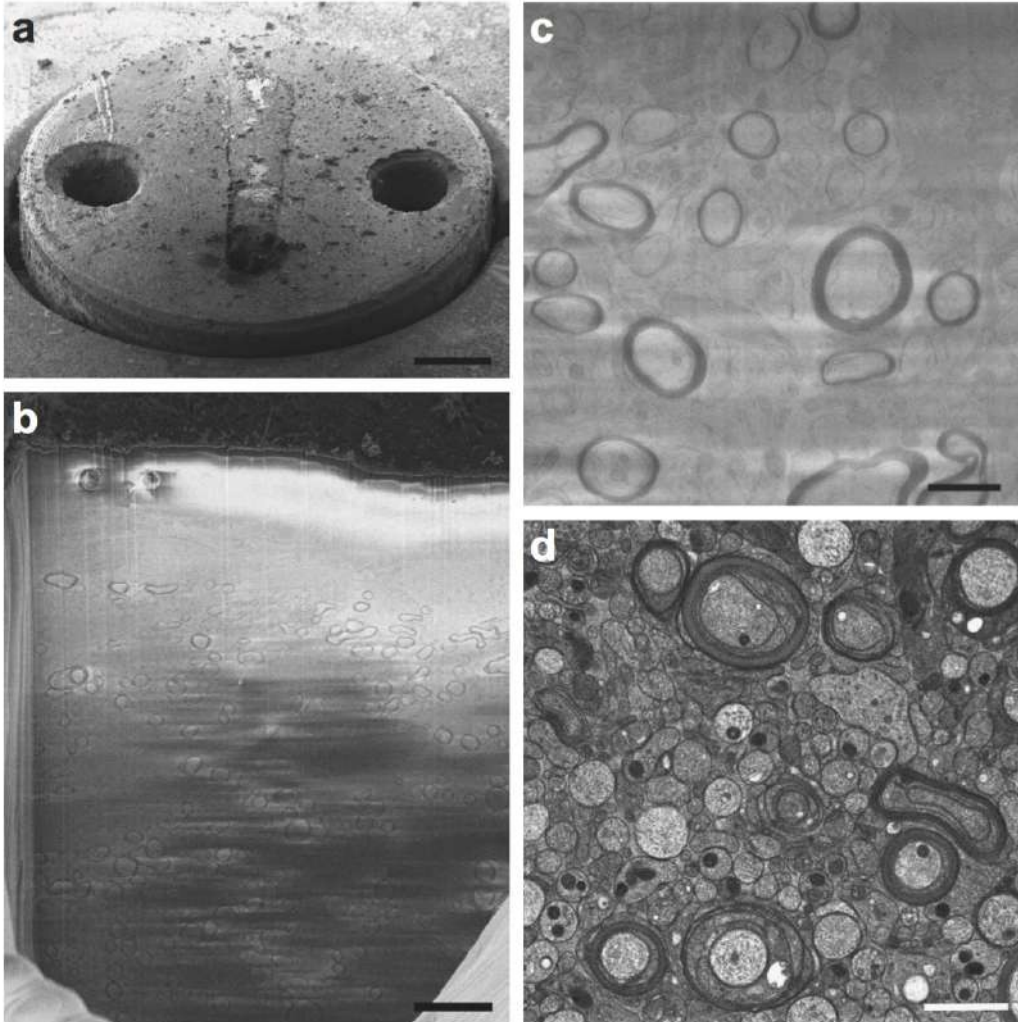
^c Department of Systemic Cell Biology, Max-Planck-Institute of Molecular Physiology, Otto-Hahn-Straße 11, D-44227 Dortmund, Germany

^d Department of Neurogenetics, Electron Microscopy Facility, Max-Planck-Institute of Experimental Medicine, Hermann-Rein-Straße 3, D-37075 Göttingen, Germany

^e Advanced Light and Electron Microscopy, Centre for Biological Threats and Special Pathogens, Robert Koch Institute, Nordufer 20, D-13353 Berlin, Germany

^f Center for Nanoscale Microscopy and Molecular Physiology of the Brain (CNMPB), Göttingen, Germany

In-lens SE detector at 2.33 kV



Technical Note

Cryo FIB-SEM: Volume imaging of cellular ultrastructure in native frozen specimens



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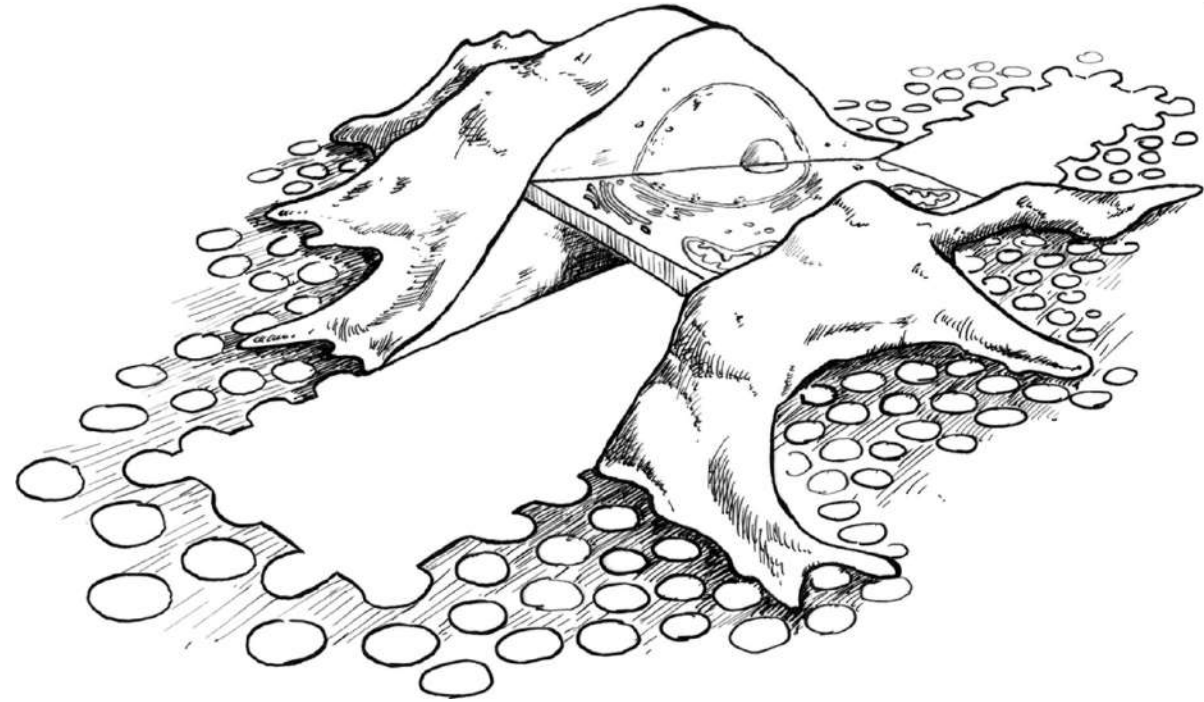
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Cryo FIB/SEM for tomographic sample preparation



2005: Shown that FIB milled cryo specimens remain vitreous

Journal of Microscopy, Vol. 222, Pt 1 April 2006, pp. 42–47

Received 8 July 2005; accepted 21 December 2005

Focused ion beam milling of vitreous water: prospects for an alternative to cryo-ultramicrotomy of frozen-hydrated biological samples

M. MARKO, C. HSIEH, W. MOBERLYCHAN*,

C. A. MANNELLA & J. FRANK*†

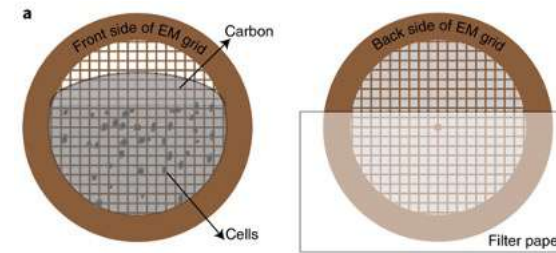
Resource for Visualization of Biological Complexity, †Howard Hughes Medical Institute, Wadsworth Center, Empire State Plaza, Albany, NY 12201, U.S.A.

*Center for Nanoscale Systems, Harvard University, 17 Oxford St., Cambridge, MA 02138, U.S.A.

Key words. Cryo-EM, devitrification, electron tomography, FIB, frozen-hydrated specimens, vitreous ice.

Place cells on Grids

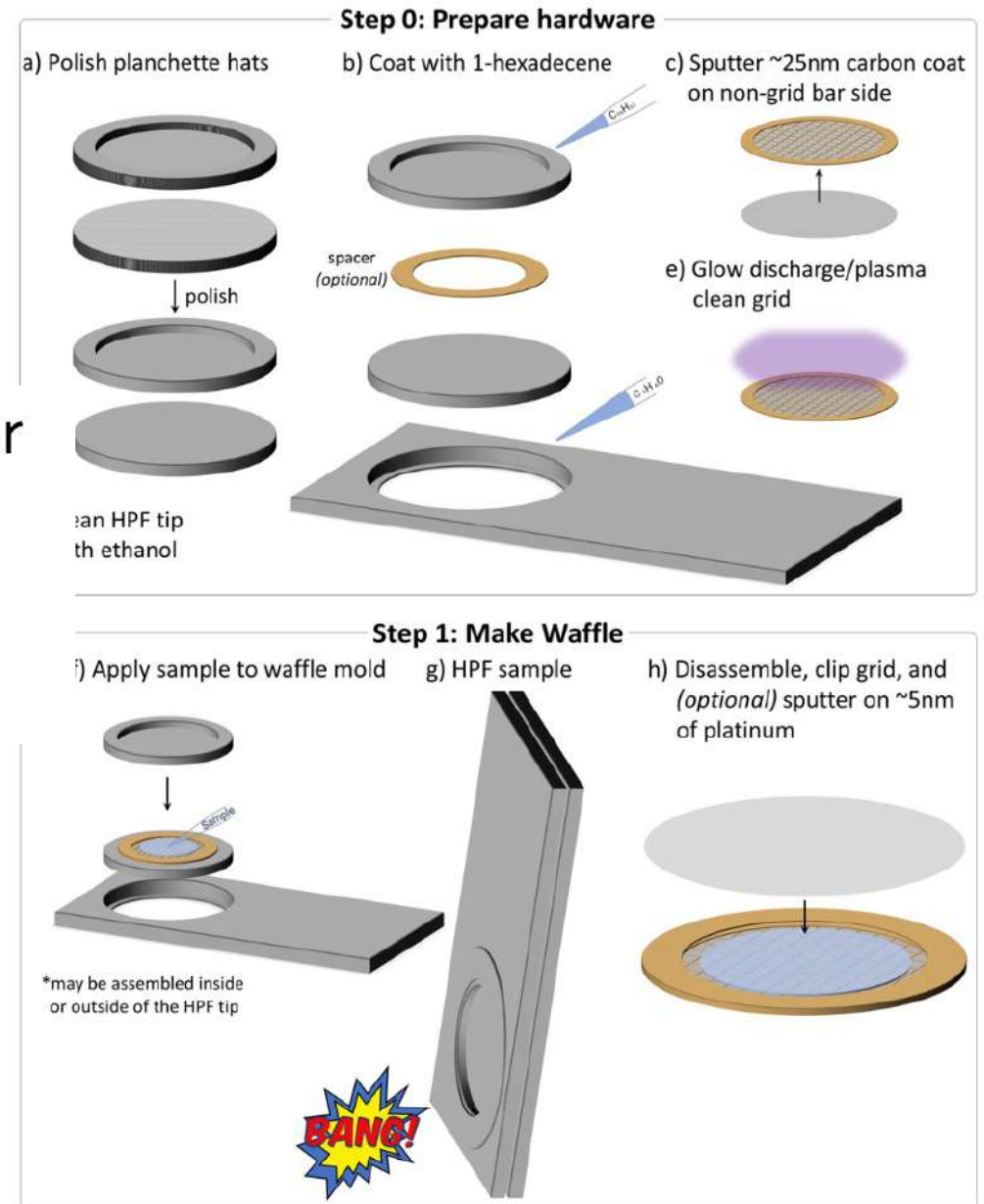
- Need gold grids, not copper, for growing cells on grids
- Cells on carbon-facing side of grid
- If cells < 10 μm thick, plunge freezing should work
 - Back-blot to freeze grid
- For thicker specimens, a high pressure freezer is needed to vitrify



HPF on grids

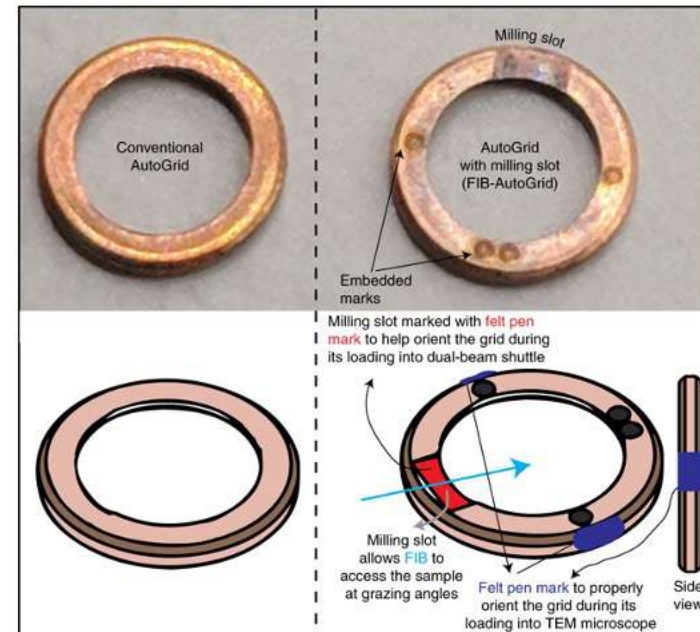
Waffle Method: A general and flexible approach for improving throughput in FIB-milling

Kotaro Kelley^{1,6}, Ashleigh M. Raczowski^{1,4,5}, Oleg Klykov^{1,2,5}, Pattana Jaroenlak^{3,5}, Daija Bobe^{1,5}, Mykhailo Kopylov¹, Edward T. Eng¹, Gira Bhabha³, Clinton S. Potter^{1,2}, Bridget Carragher^{1,3} & Alex J. Noble¹



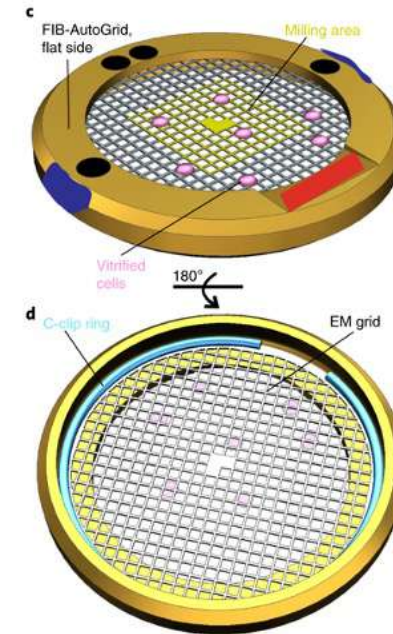
Grid Geometry

- After freezing, grids need to be clipped
 - Protection
 - Krios/Arctica
- Important to mark the autogrid!
- Autogrids with milling slot are commercially available
 - Milling slot allows lower angle of approach from ion beam



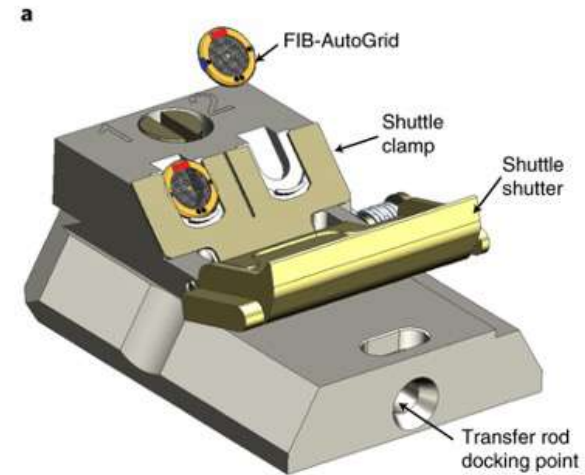
Grid Geometry

- Only the center of the grid is suitable for milling
- Cells are on flat-side of cartridge



Sample Shuttle

- Shuttle for loading grids into FIB SEM
- 2 grids at a time
- Geometry needs to be known
- Grids are pre-tilted 45°
- Shutter to protect grids

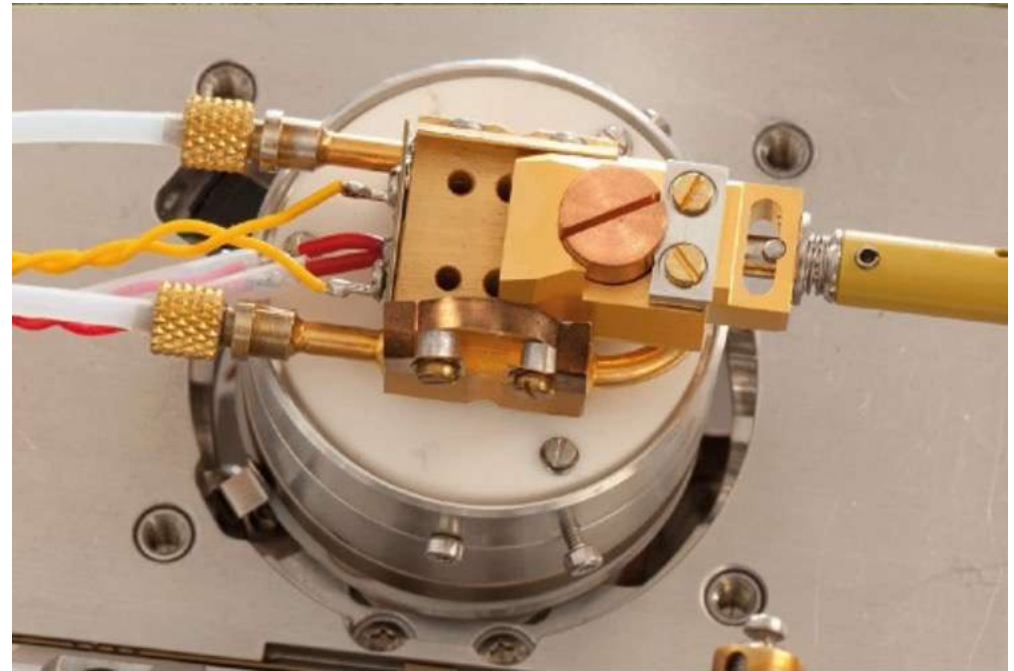


Transfer Shuttle and Cryostage on Fib SEM

Leica EM VCT500 transfer shuttle

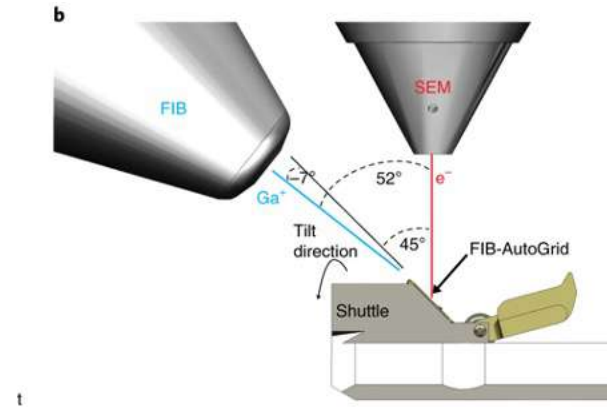


Quorum 3010 stage



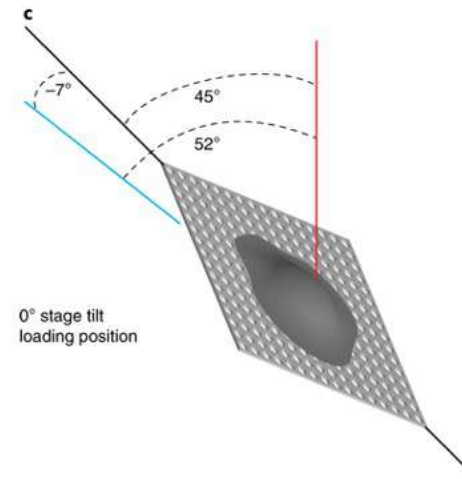
Geometry

- Untilted stage:
 - Ga beam at -7° angle to grid surface
 - E-beam at 45° angle to grid surface



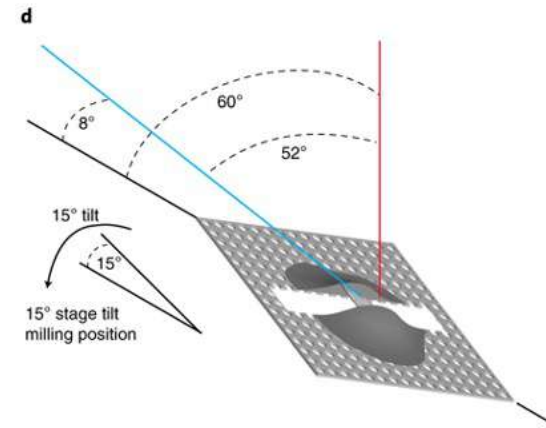
Geometry: Untilted

- Untilted stage:
 - Ga beam at -7° angle to grid surface
 - E-beam at 45° angle to grid surface



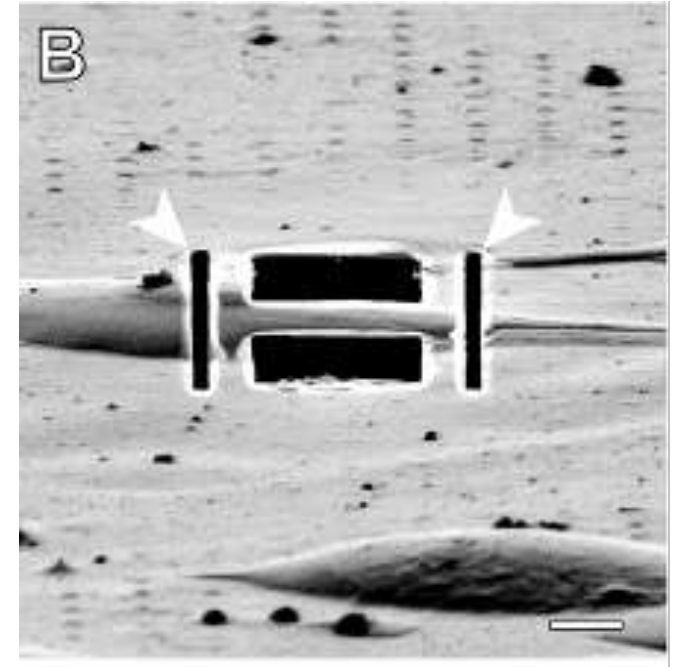
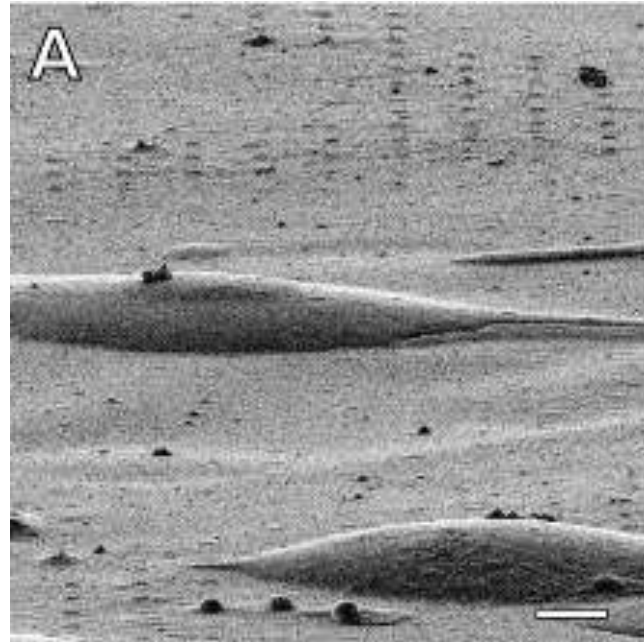
Geometry: Tilted

- Tilt stage +15°
 - Ga beam at +8° angle to grid surface
 - E-beam at 60° angle to grid surface

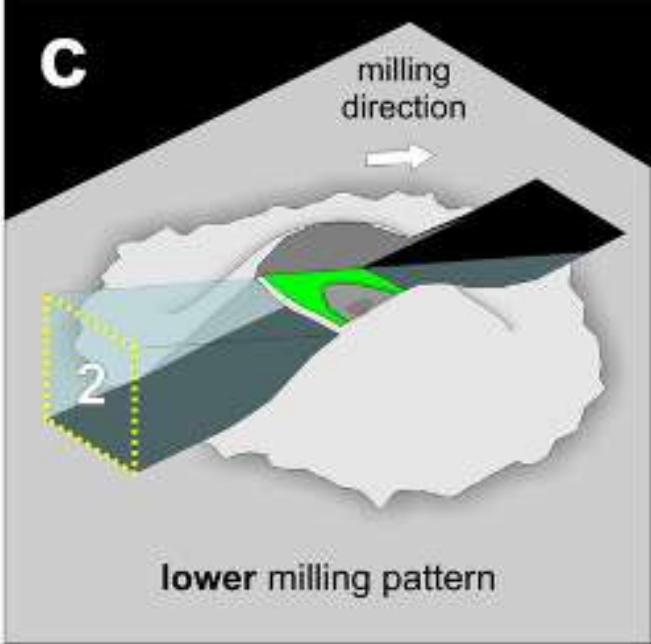
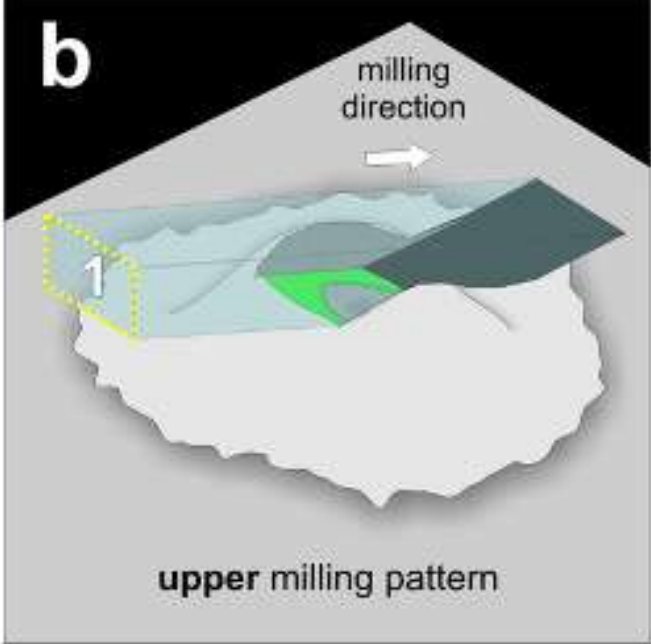
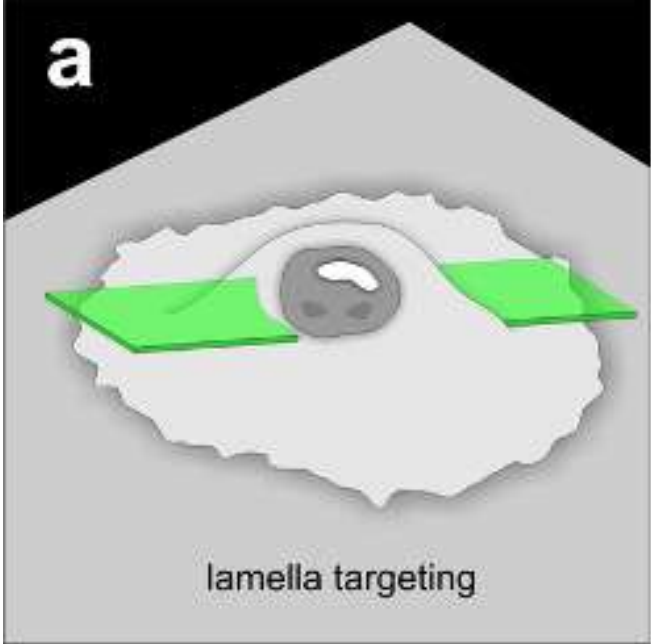


Imaging cells with ion beam

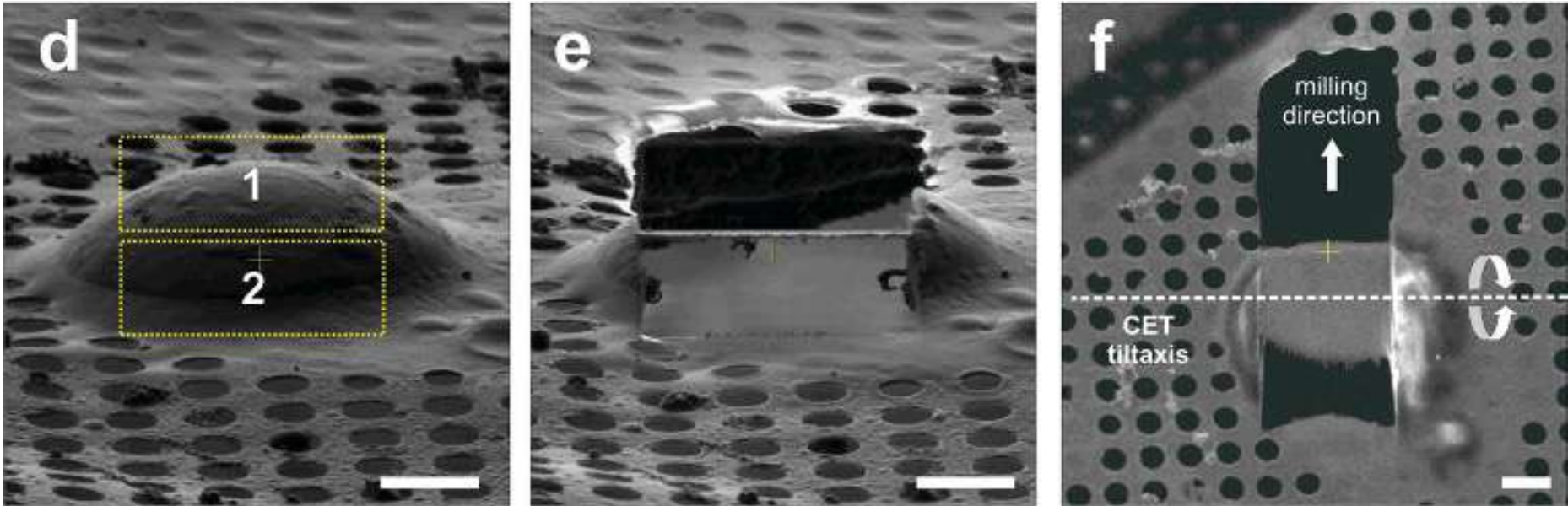
- A: Ion-beam view of cells
- B: Cells after milling, showing position of micro-expansion joints



Targeting of Milling Regions

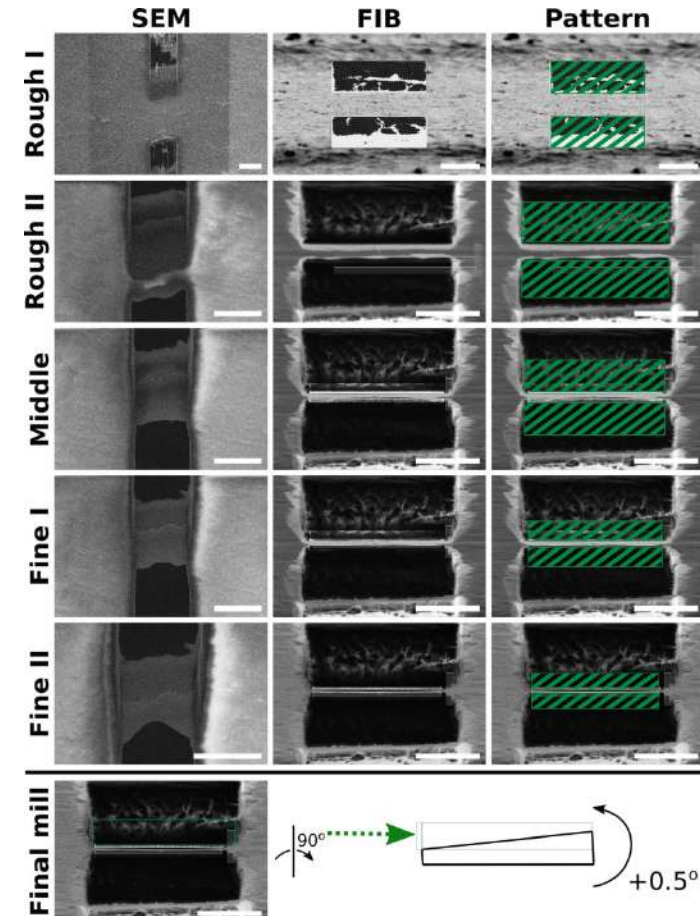


Targeting of Milling Regions

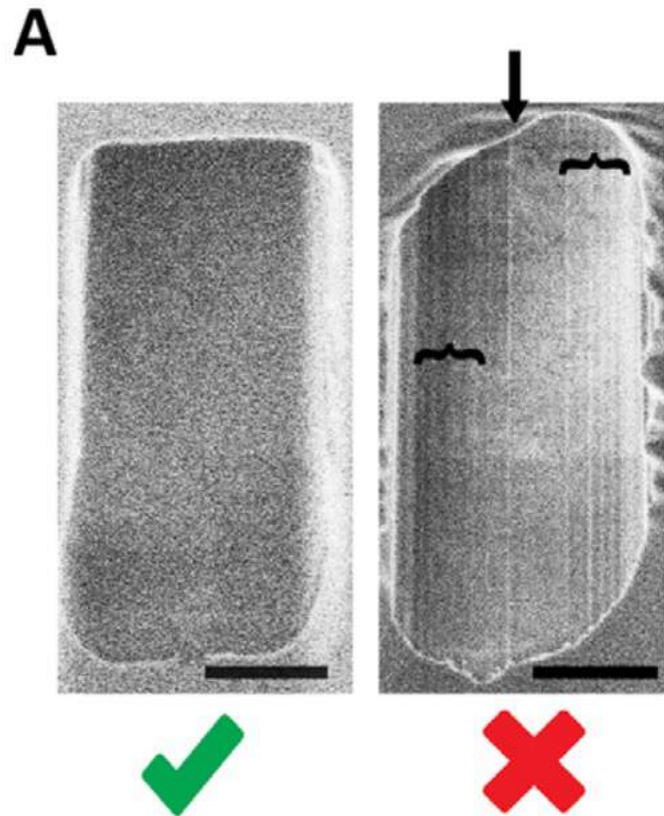


Milling

- In practice, milling is done in several steps
 - Rough cuts
 - Finer and finer polishing steps
 - Start at high current, finish at low current
 - Final step: additional 0.5° tilt to make lamellae even thickness throughout section
- Higher throughput
 - Target several regions and do rough mills
 - After all rough work is done, do final polishing and remove from SEM

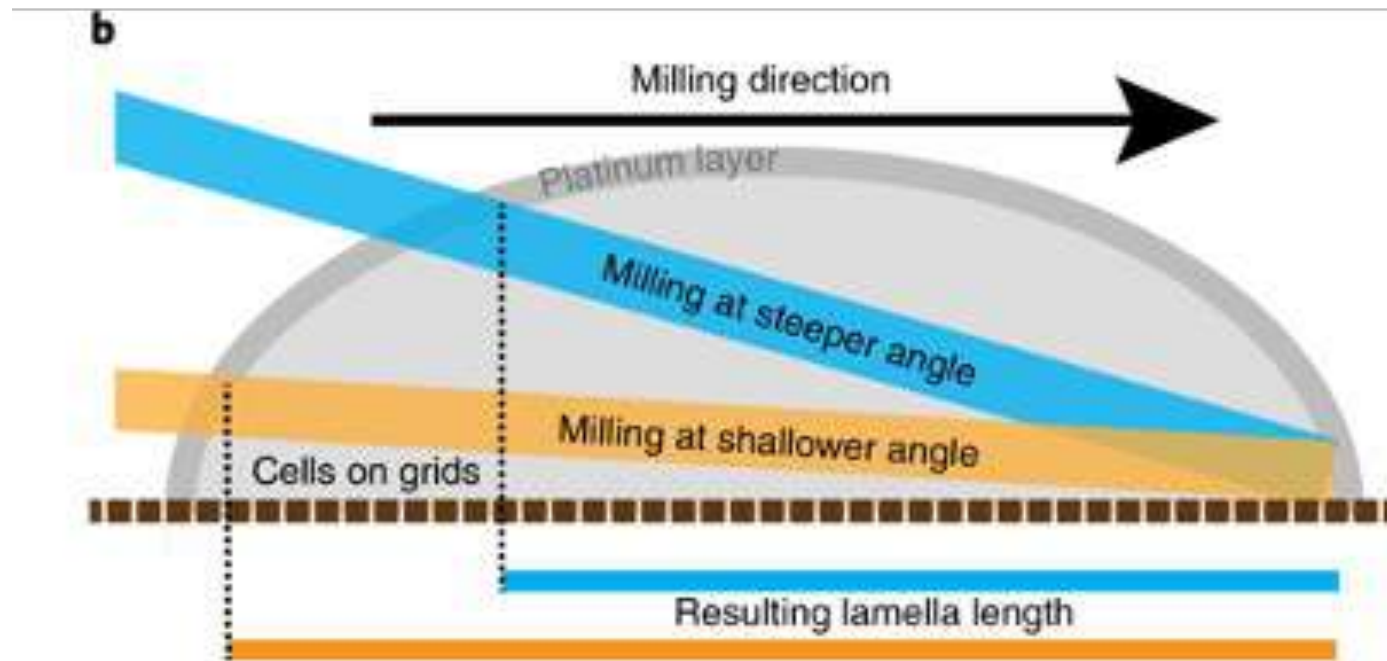


Curtaining



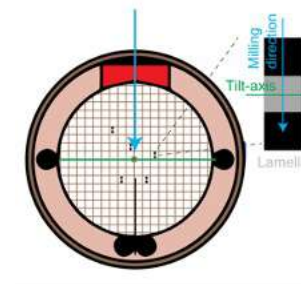
- Ideally the cutting from the ion beam will leave a perfectly flat face
- Uneven interactions with the surface can result in uneven milling which shows up as “curtains”

Milling at as shallow an angle as possible



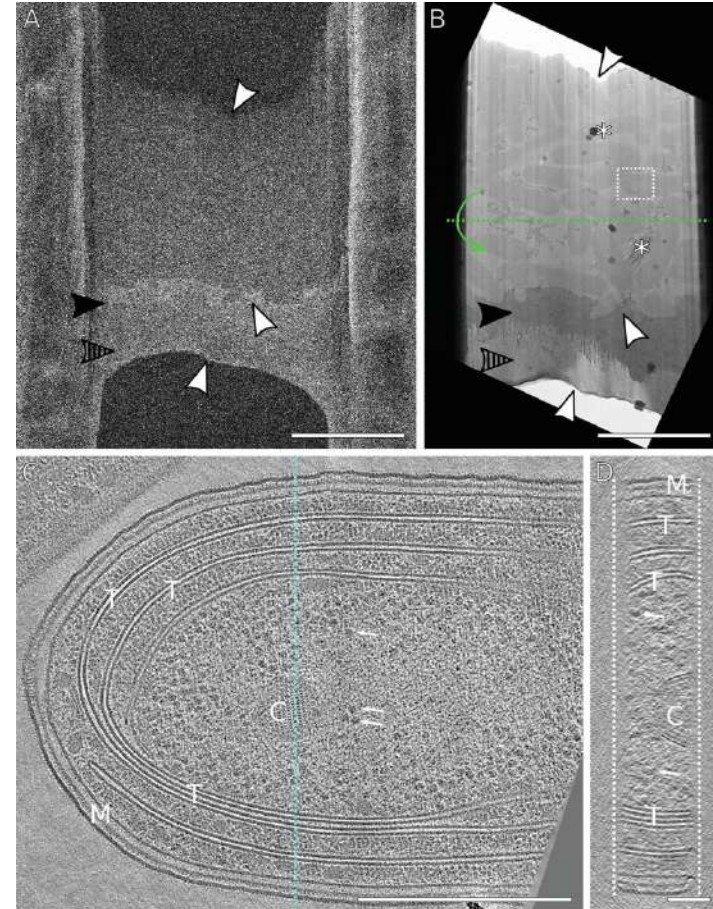
Geometry: Loading into TEM

- Sample needs to be loaded such that milling axis is perpendicular to microscope tilt axis



Ideal Result

- A: Image of prepared lamella using e-beam in FIB SEM
- B: Image of same region taken in Titan Krios. White arrows mark areas of correlation between (A) and (B). Solid black arrowhead: Pt from sputtering. Striped arrowhead: Pt from GIS. Green line shows the TEM tilt axis. White box: area for tilt-series acquisition. Asterisk: poor vitrification or contamination
- C: XY view of a reconstructed tomogram of a single cyanobacterium from the lamella.



Difficulties / Issues

- Geometry: Need a cryo stage which will rotate and tilt with as much freedom as possible
- Sample Charging
 - Pre-coat with Pt Sputter coat
 - Perhaps post-coat with Pt sputter as well
- Curtaining due to uneven milling
 - Cover with organic Pt layer to provide even surface
- Lamella Bending
 - Cut notches for stress relief
- Contamination
 - Vacuum is much worse than inside a TEM, contamination buildup limits the number of lamella which can be produced
 - All sample transfer steps have the danger of adding contamination

Article

<https://doi.org/10.1038/s41467-023-36372-9>

Plasma FIB milling for the determination of structures in situ

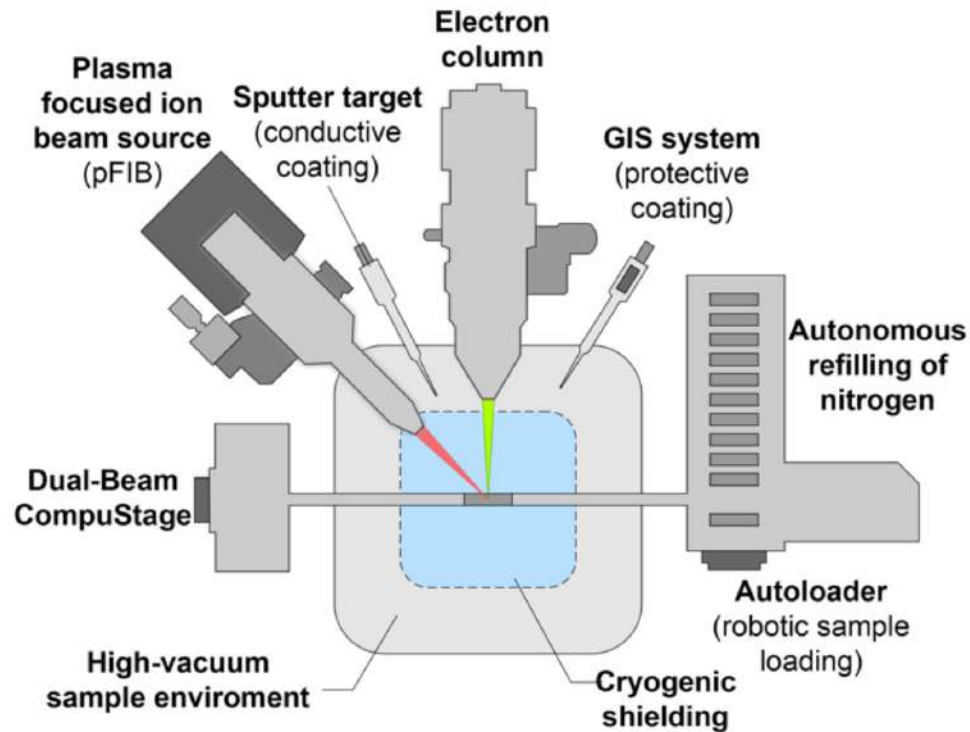
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Plasma instead of Ga



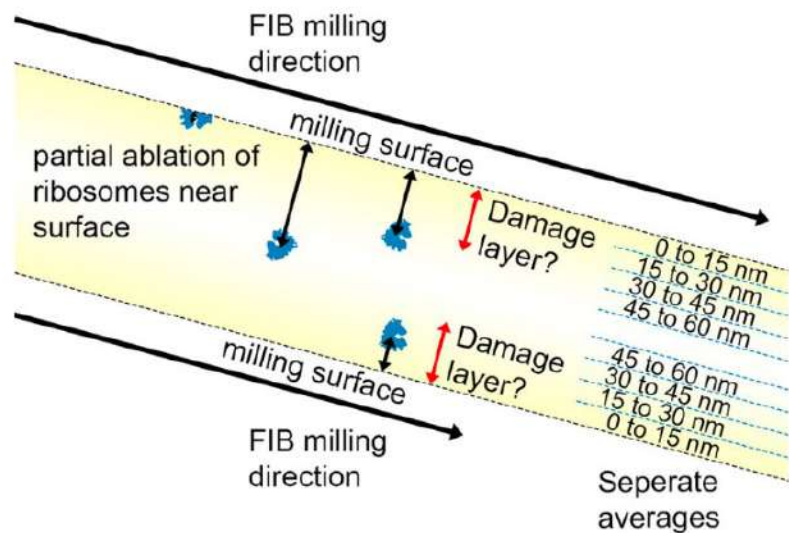
- Typical Gases: Ar, Xe, O₂, N₂
- No worry about deposition/implantation
- Faster bulk material removal
- More expensive instrument

Milling Rates for Plasma (Berger et al, 2023)

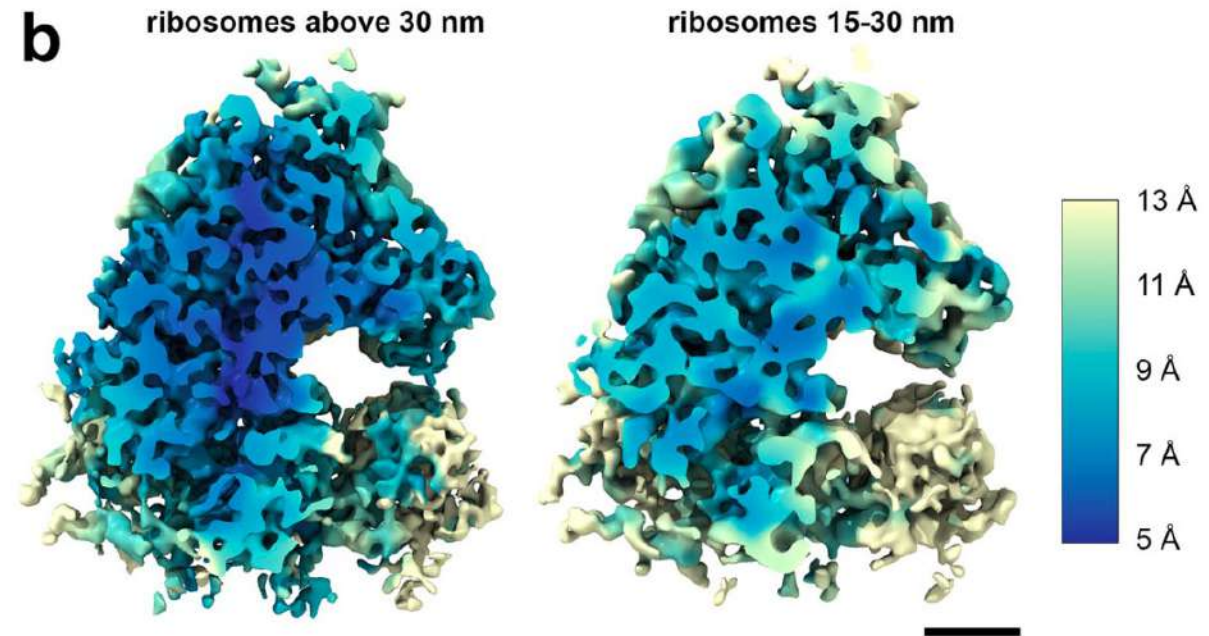
Beam	Xe	N	O	Ar	Ga
Milling rate ($\mu\text{m}^3/\text{nC}$)	16.7 +/- 0.2	10.6 +/- 0.2	10.0 +/- 0.4	4.3 +/- 0.1	7.7

Damage near the lamella surface

a



b



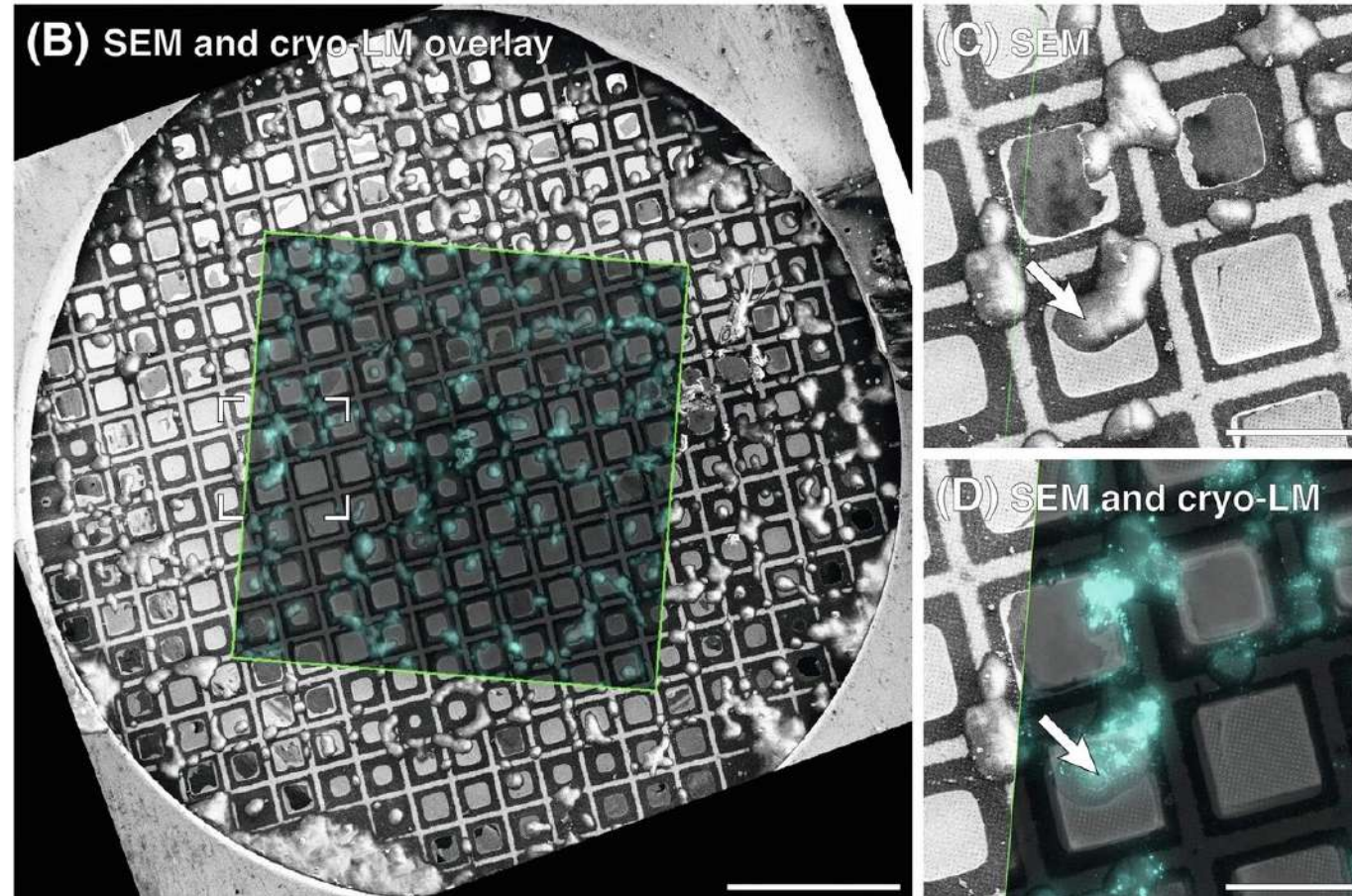
Where to mill?

- Unless all cells are the same, you need to be able to determine which are the target cells
- Also which part of the cell to keep
- Solution: Another microscope!
 - Fluorescent light microscopes with cryo stages are available
 - Need to have a long working distance, cannot use oil immersion, relatively high NA
 - Z signal is lowest resolution, confocal not available
 - Latest microscopes have software to import and correlate LM images with SEM images for localization
 - More transfers lead to increased danger of contamination / damage
 - Place FLM inside SEM chamber

Cryo-CLEM: Correlate points between images



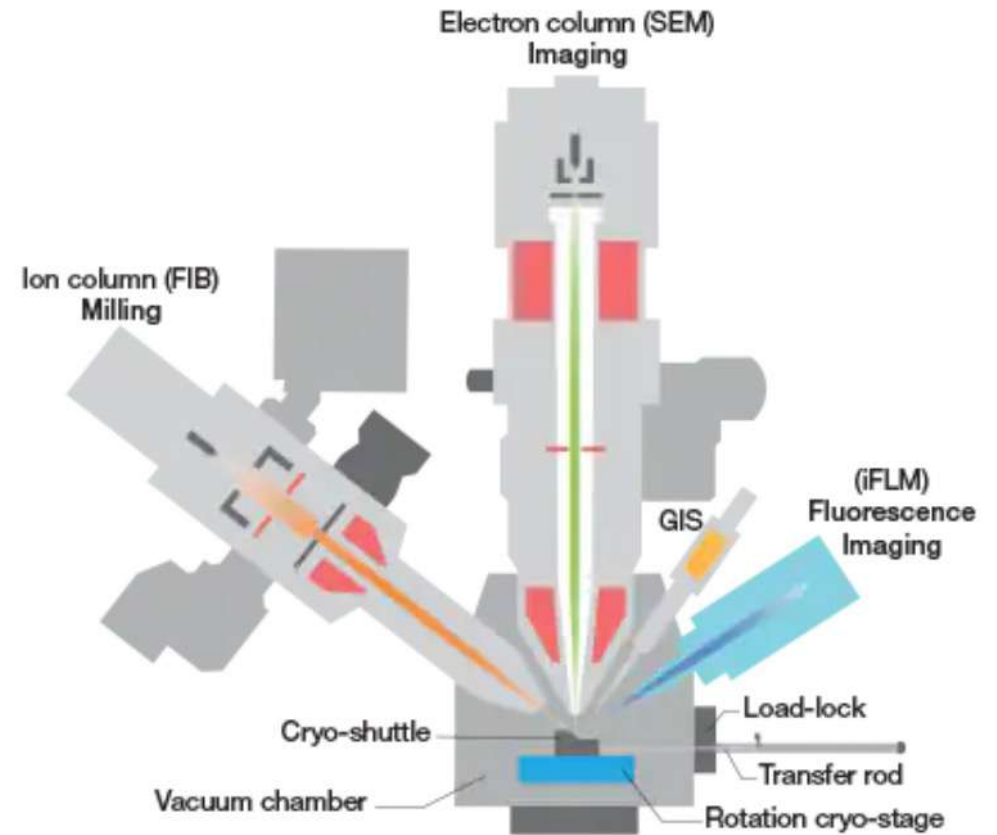
Cryo-CLEM: Overlay



Summary: Equipment and expertise needed

- FIB SEM
 - Cryo stage with full rotation
 - GIS or plasma (Ar/Xe/O₂/N₂) source
 - Sputter coater
 - Shuttles and transfer equipment
 - Software for mapping and overlaying signals
 - Integrated FLM
- Cryo LM
 - Compatible cryo stage
 - Fluorescent signal detection
 - Shuttles and transfer equipment
- TEM
 - Suitable for high resolution tomography
 - 300 keV, direct detector, energy filter

Specialized Microscopes: Aquilos 2 Cryo FIB

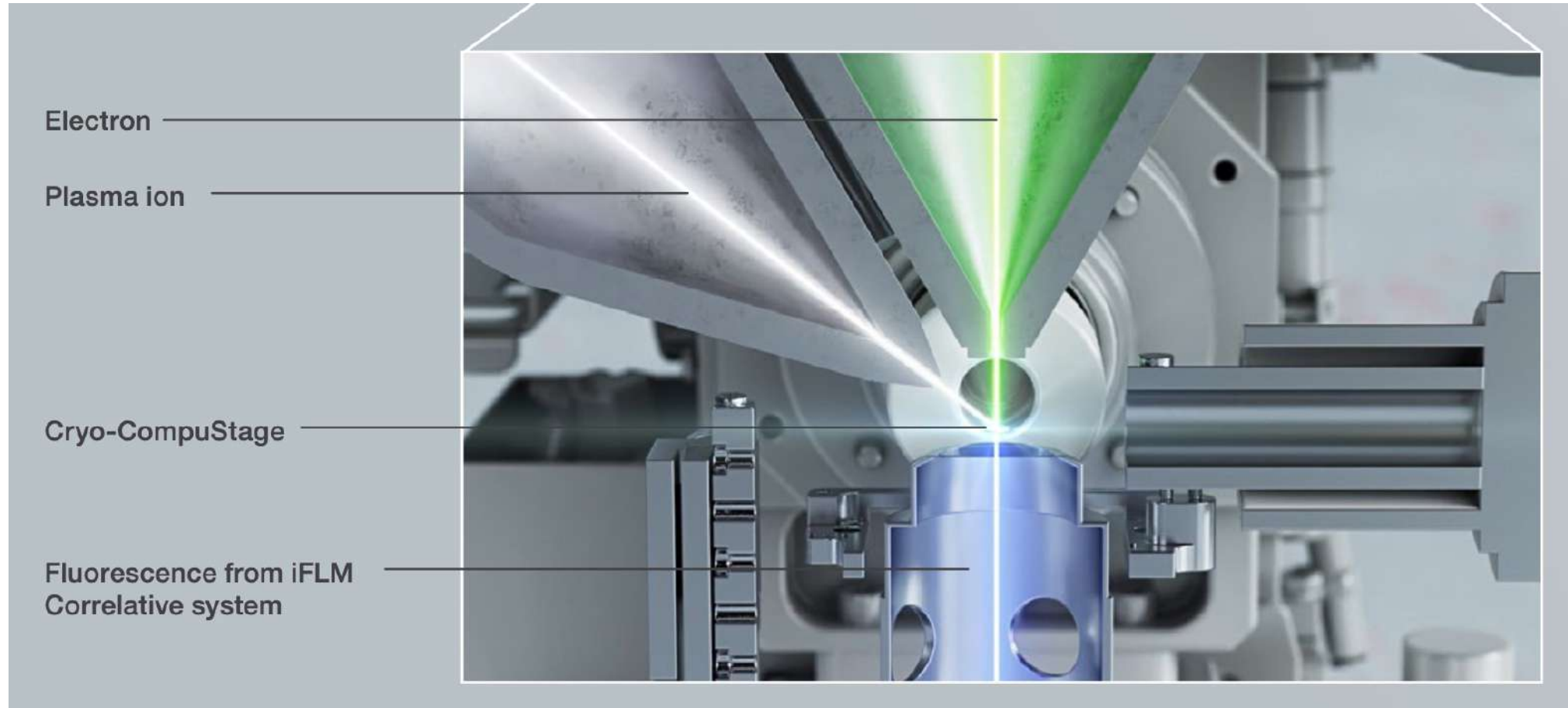


Specialized Microscopes: Arctis Plasma FIB



- Dedicated to lamella generation only
- Autoloader system
- Small chamber
- Plasma FIB instead of Ga

Arctis Plasma FIB



Questions

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